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Silverbrook

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(54) **METHOD OF MANUFACTURE OF A COIL ACTUATED MAGNETIC PLATE INK JET PRINTER**

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(*) Notice: Subject to any disclaimer, the term of this patent is extended or adjusted under 35 U.S.C. 154(b) by 0 days.

This patent is subject to a terminal disclaimer.

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(30) **Foreign Application Priority Data**

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(52) **U.S. Cl.** 216/27; 347/54; 347/55;
347/53; 347/63; 347/56

(58) **Field of Search** 216/27; 347/54-63,
347/53

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Primary Examiner—Randy Gulakowski

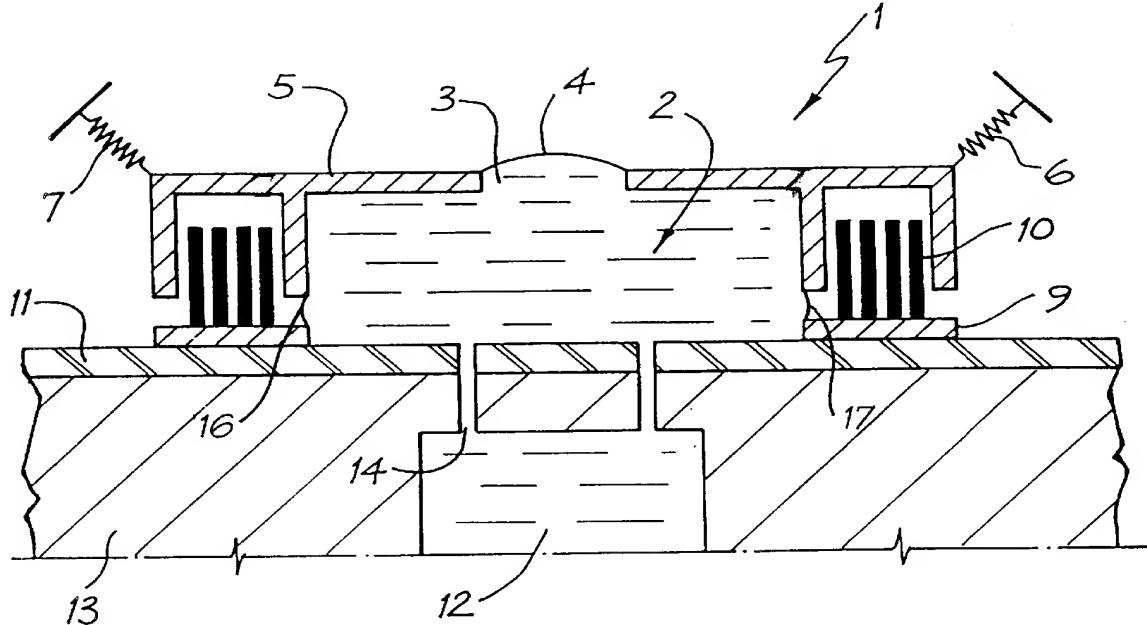
Assistant Examiner—Shamim Ahmed

(57)

ABSTRACT

A method of manufacture of an ink jet print head arrangement is disclosed including a series of nozzle chambers, the method comprising the steps of: (a) utilizing an initial semiconductor wafer having an electrical circuitry layer formed thereon; (b) etching a series of slots in at least the circuitry layer to define a nozzle cavity inlet; (c) depositing and etching a first layer of magnetic flux material on the electrical circuitry layer to define a first magnetic plate; (d) depositing and etching a insulating layer on the first layer and the electrical circuitry layer, the etching including etching vias for a subsequent conductive layer; (e) depositing and etching a conductive layer in form of a conductive coil conductively interconnected to the electrical circuitry layer; (f) depositing and etching a hydrophobic material layer in the region of the conductive coil; (g) depositing and etching a sacrificial material layer in the region of the first magnetic plate and the coil, the etching including defining a cavity for the walls of a nozzle chamber; (h) depositing and etching a second layer of magnetic flux material over the sacrificial material so as to substantially enclose the conductive coil; (i) etching away the sacrificial material; (j) etching an ink supply channel through the wafer to form a fluid communication with the nozzle chamber.

8 Claims, 9 Drawing Sheets



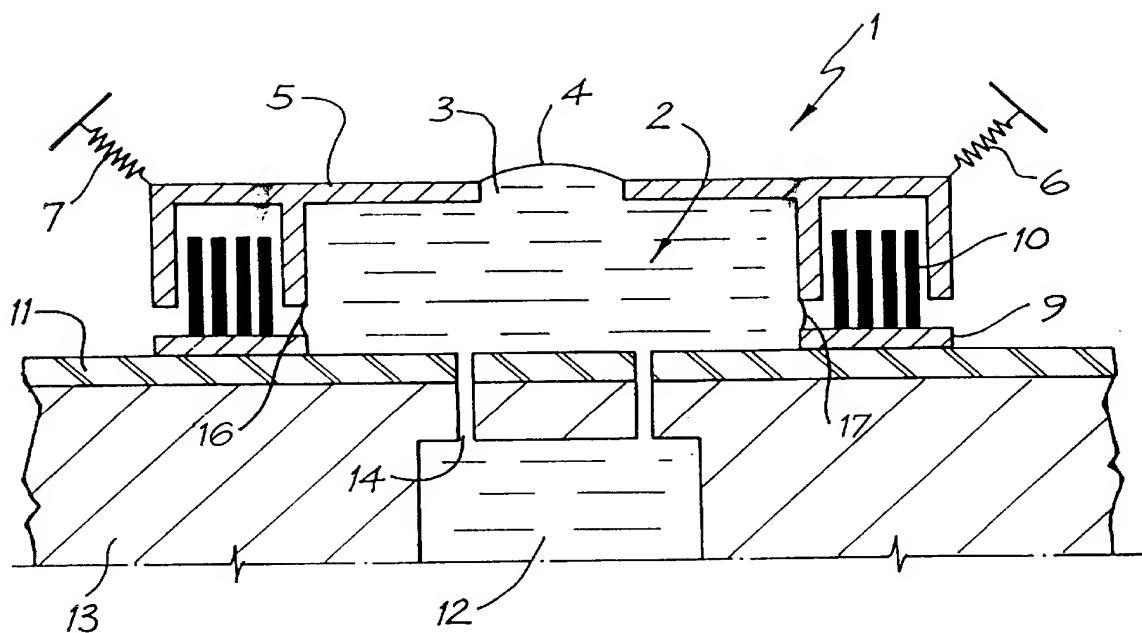


FIG. 1

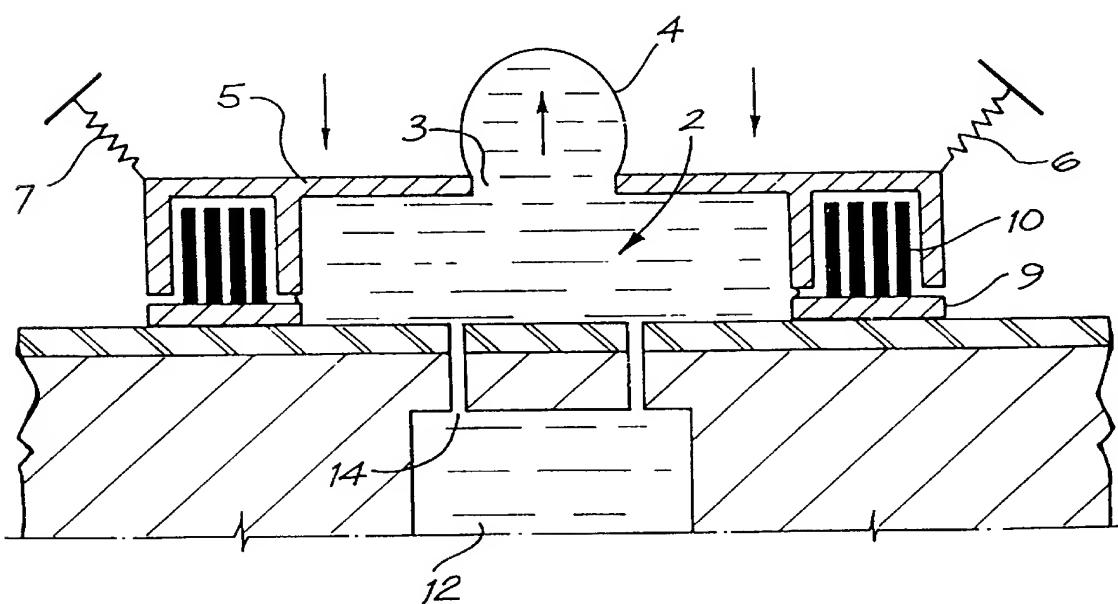


FIG. 2

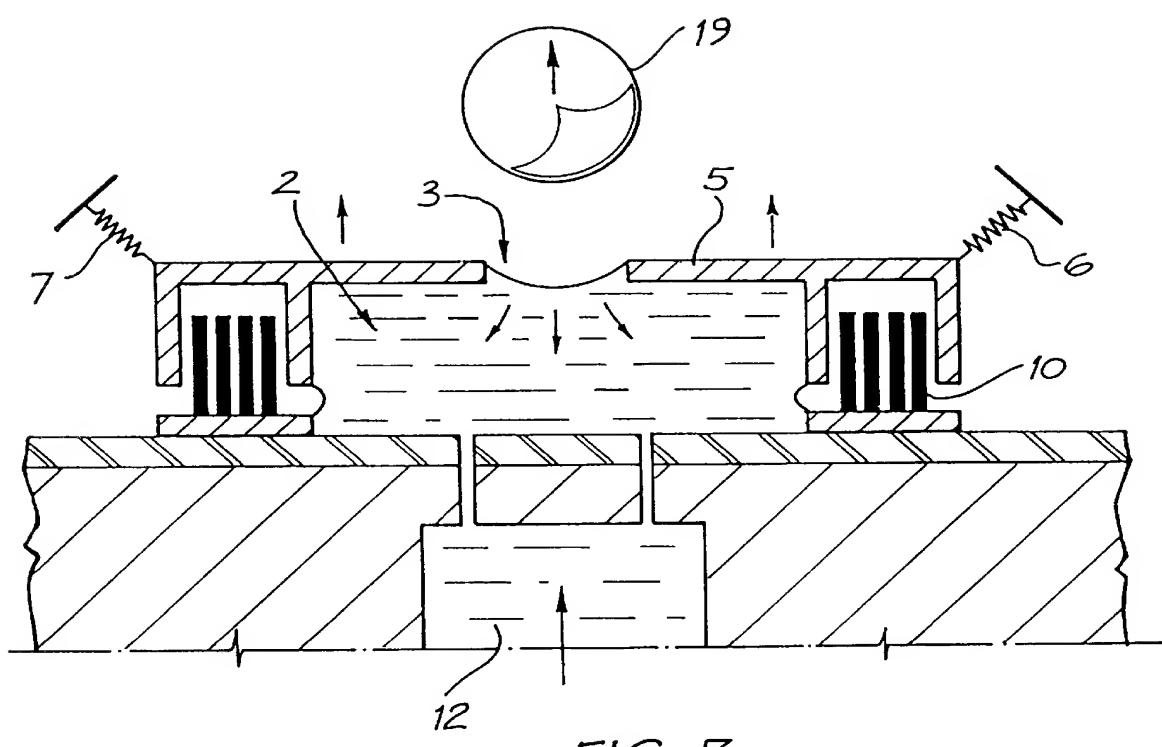


FIG. 3

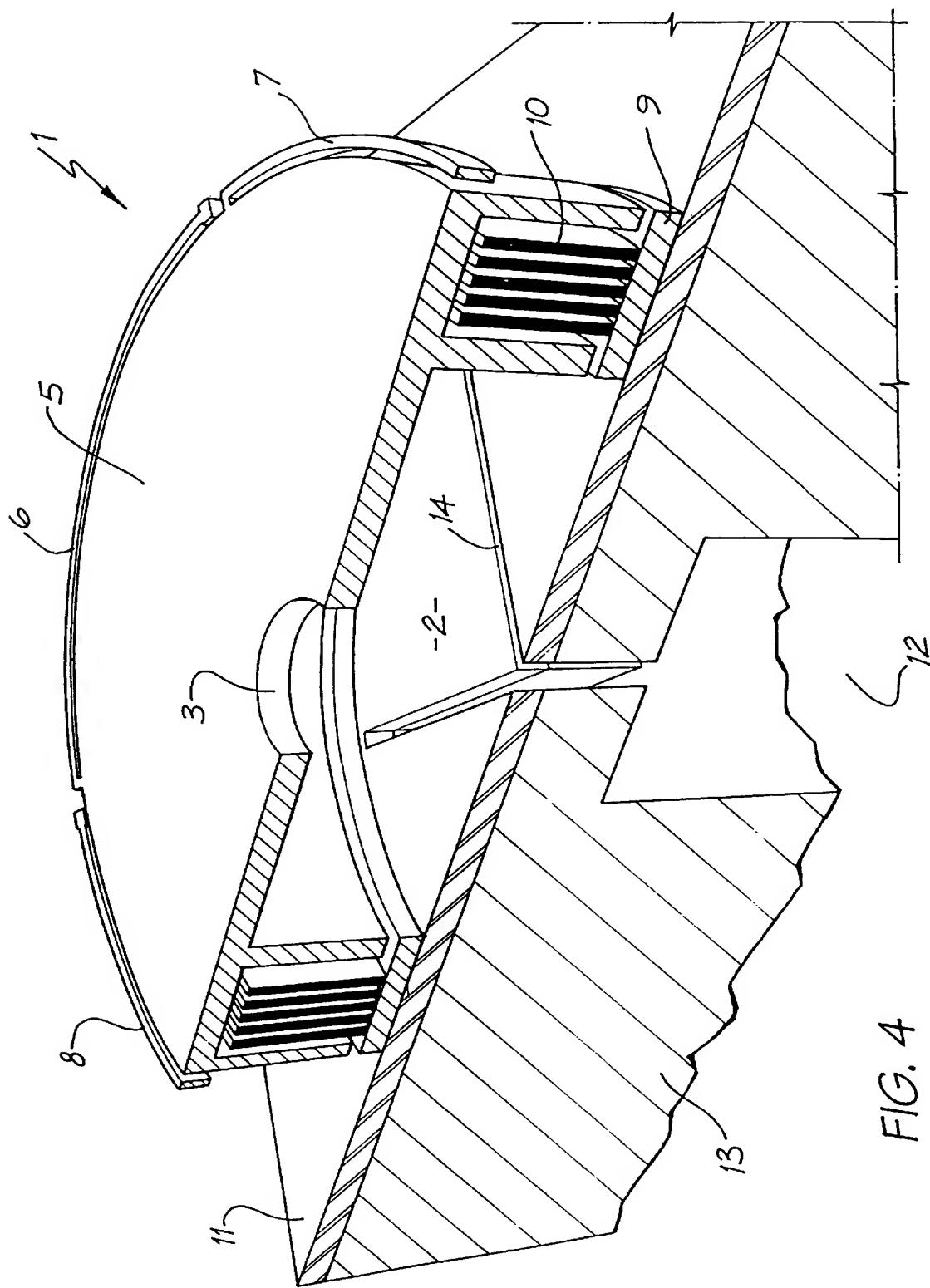


FIG. 4

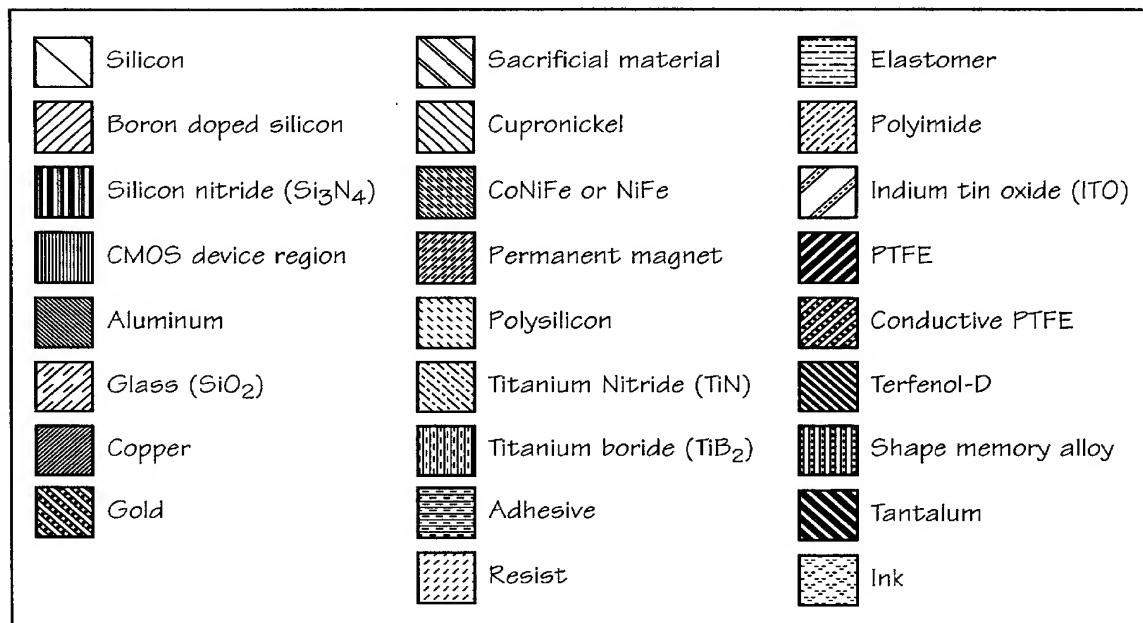


FIG. 5

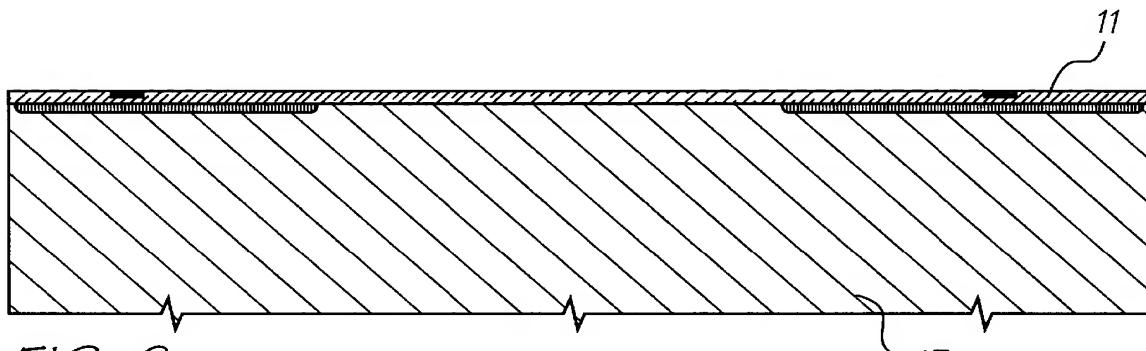


FIG. 6

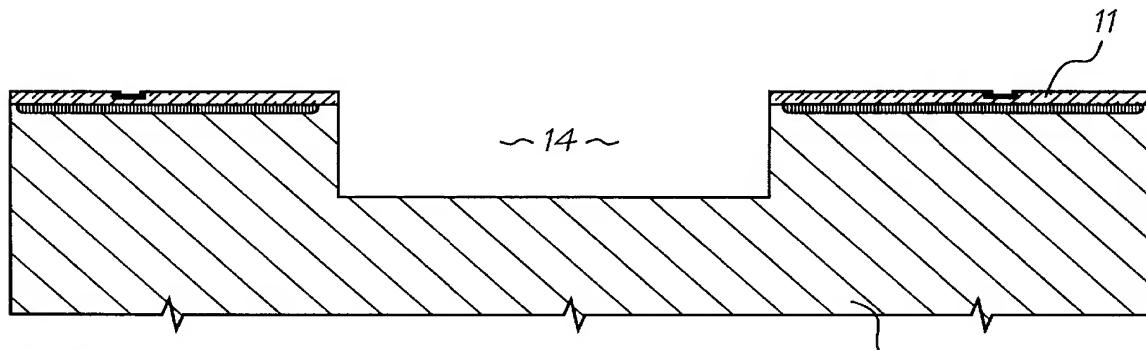
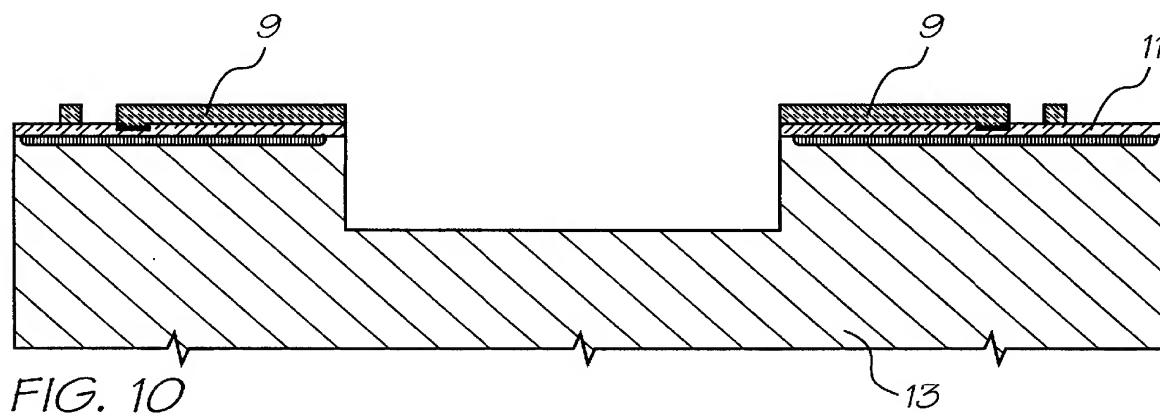
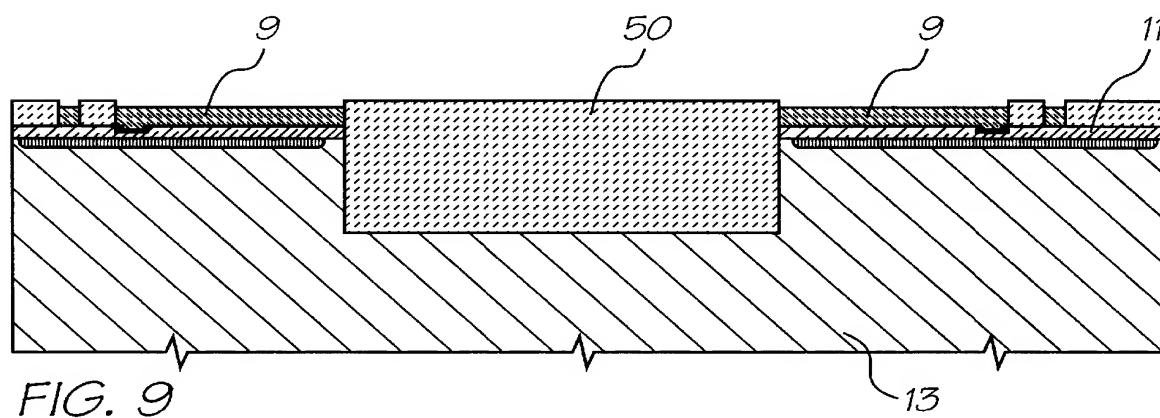
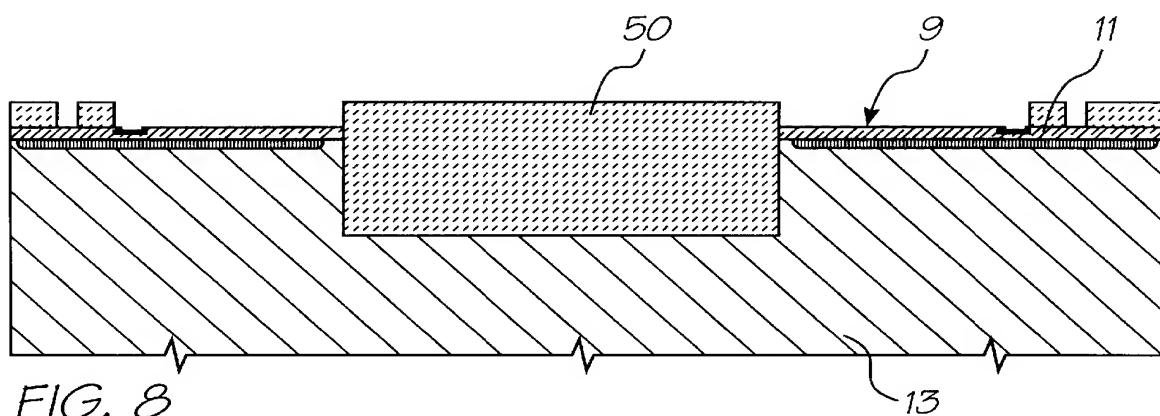


FIG. 7



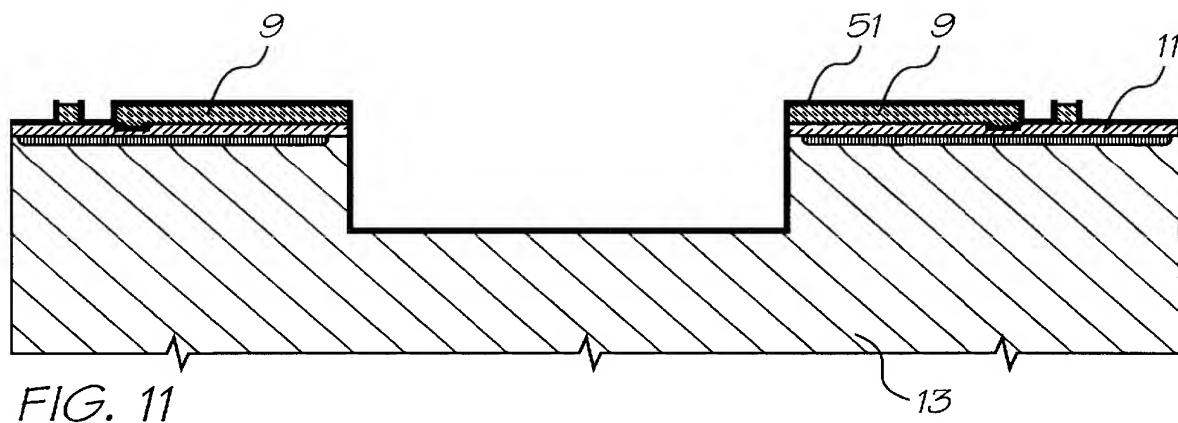


FIG. 11

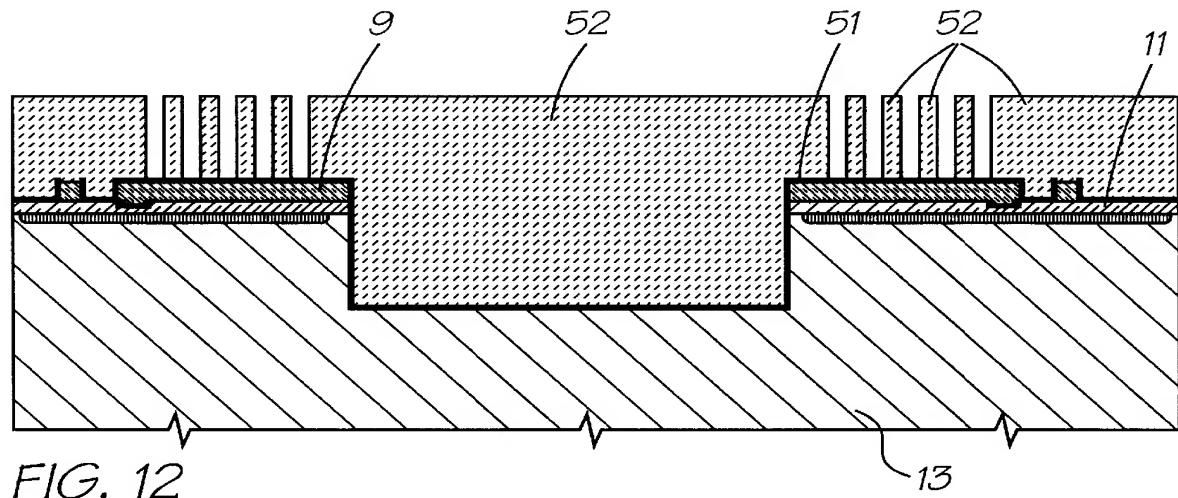


FIG. 12

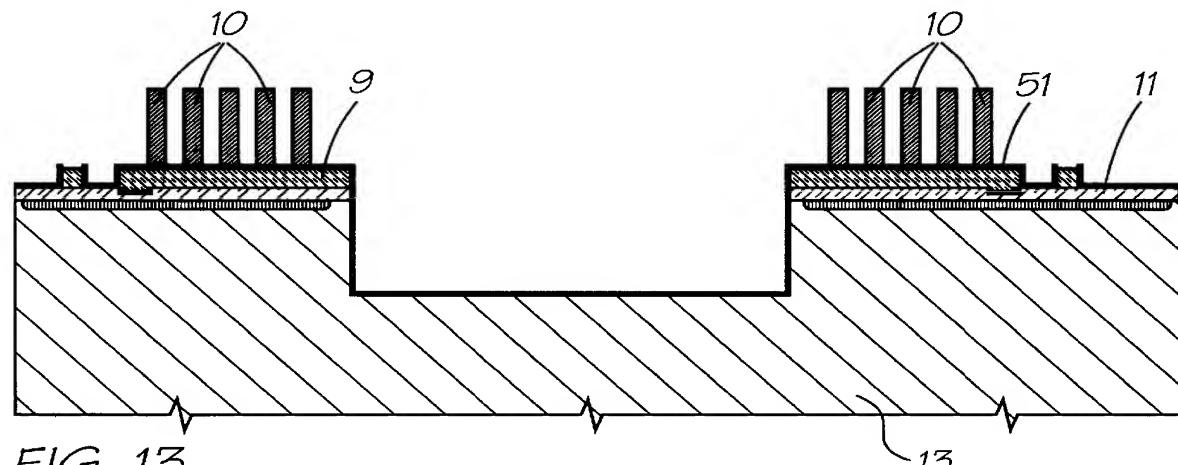


FIG. 13

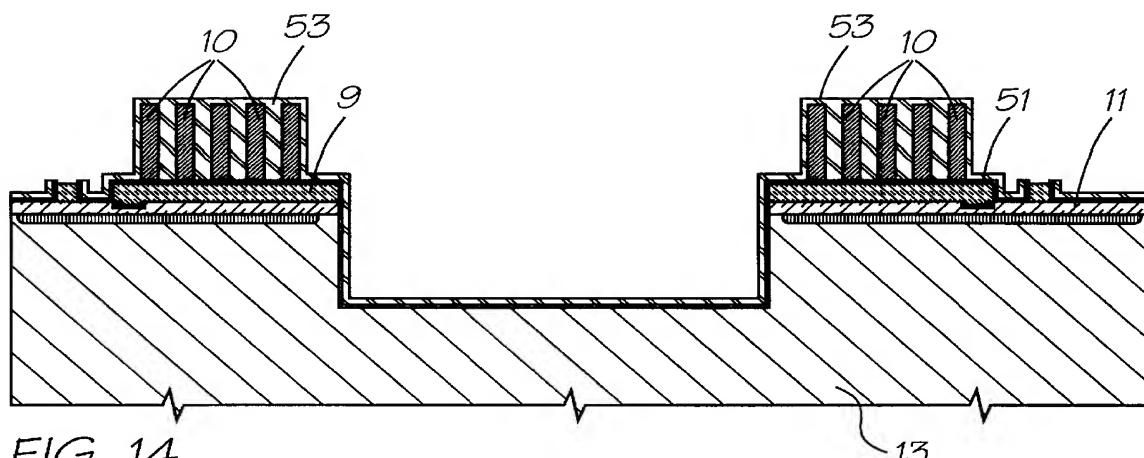


FIG. 14

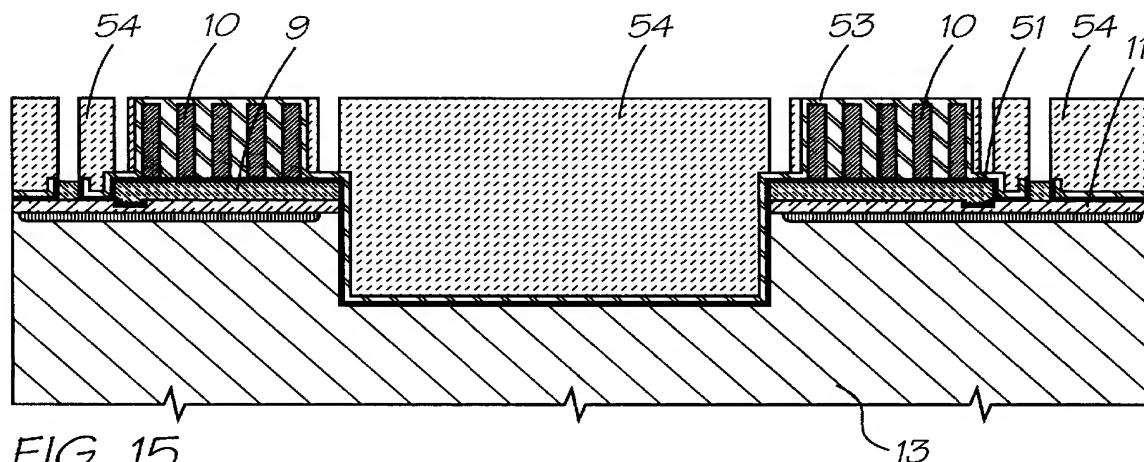


FIG. 15

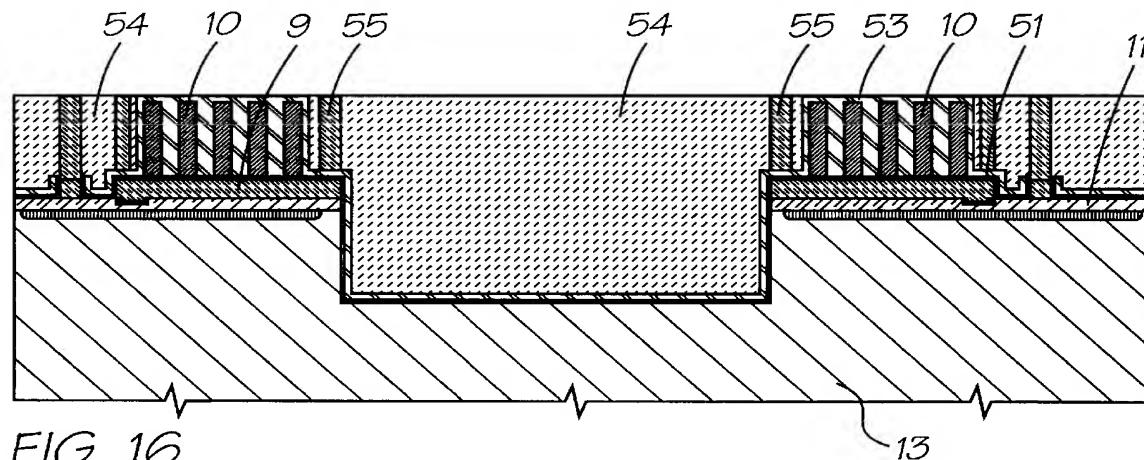


FIG. 16

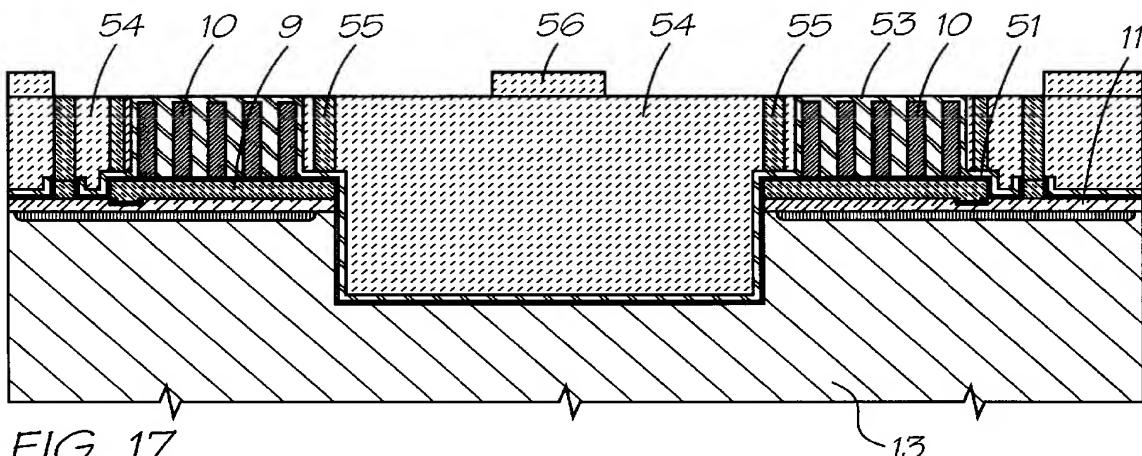


FIG. 17

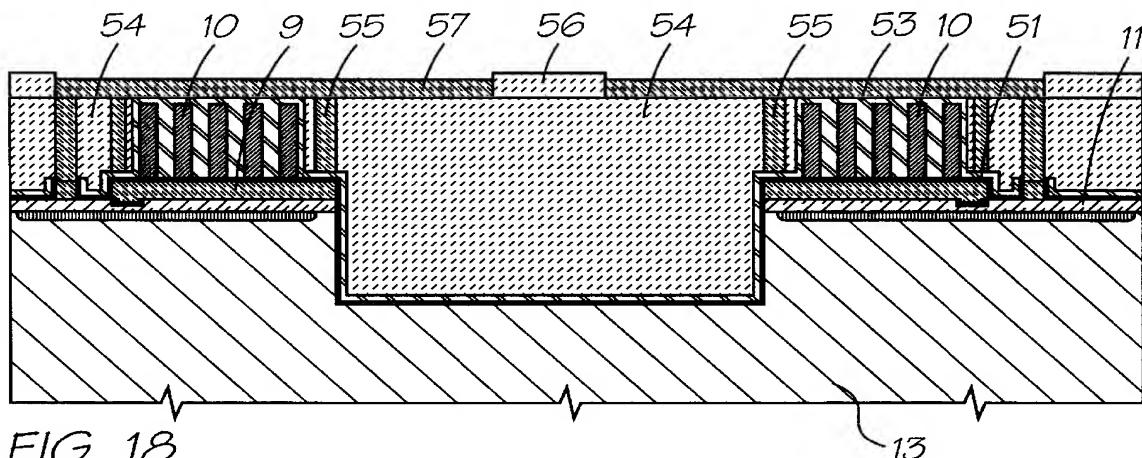


FIG. 18

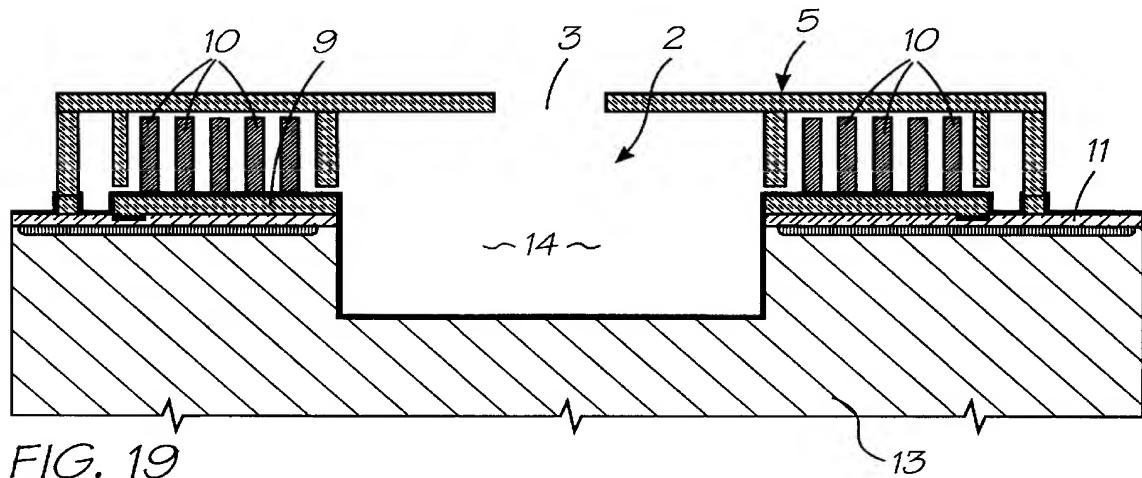
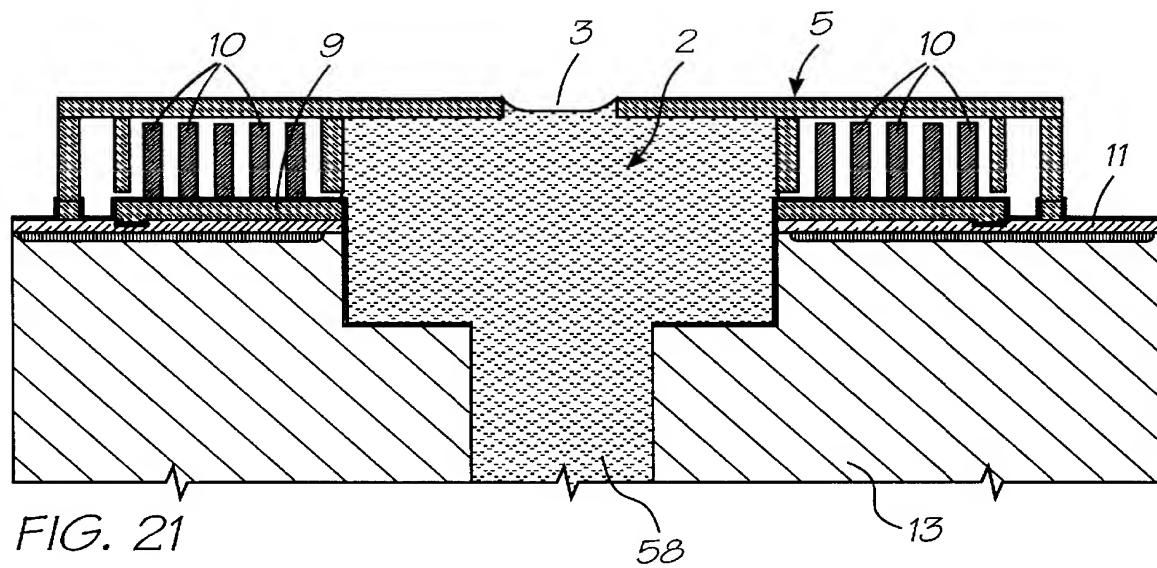
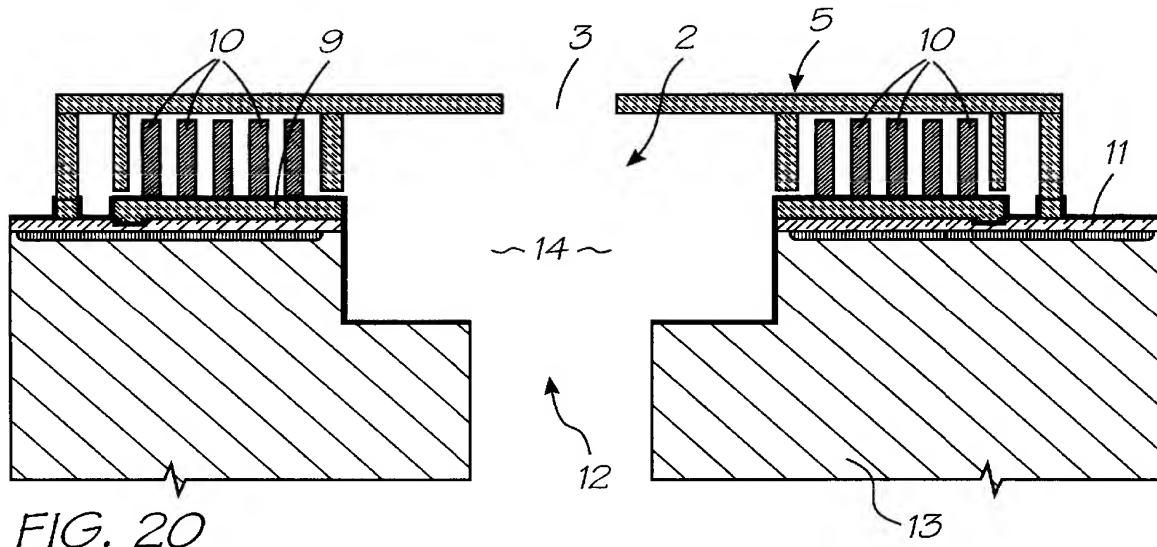


FIG. 19



**METHOD OF MANUFACTURE OF A COIL
ACTUATED MAGNETIC PLATE INK JET
PRINTER**

CROSS REFERENCES TO RELATED
APPLICATIONS

5

of location and identification, U.S. patent applications identified by their U.S. patent application serial numbers (USSN) are listed alongside the Australian applications from which the U.S. patent applications claim the right of priority.

The following Australian provisional patent applications are hereby incorporated by cross-reference. For the purposes

CROSS-REFERENCED AUSTRALIAN PROVISIONAL PATENT APPLICATION NO.	U.S. Pat. No. /PATENT APPLICATION (CLAIMING RIGHT OF PRIORITY FROM AUSTRALIAN PROVISIONAL APPLICATION)	DOCKET NO.
PO7991	09/113,060	ART01
PO8505	09/113,070	ART02
PO7988	09/113,073	ART03
PO9395	09/112,748	ART04
PO8017	09/112,747	ART06
PO8014	09/112,776, PN 6227648	ART07
PO8025	09/112,750	ART08
PO8032	09/112,746	ART09
PO7999	09/112,743	ART10
PO7998	09/112,742	ART11
PO8031	09/112,741	ART12
PO8030	09/112,740, PN 6196541	ART13
PO7997	09/112,739	ART15
PO7979	09/113,053	ART16
PO8015	09/112,738	ART17
PO7978	09/113,067	ART18
PO7982	09/113,063	ART19
PO7989	09/113,069	ART20
PO8019	09/112,744	ART21
PO7980	09/113,058	ART22
PO8018	09/112,777	ART24
PO7938	09/113,224	ART25
PO8016	09/112,804	ART26
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PO7939	09/112,785	ART29
PO8501	09/112,797, PN 6137500	ART30
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PO7987	09/113,071	ART32
PO8022	09/112,824	ART33
PO8497	09/113,090	ART34
PO8020	09/112,823	ART38
PO8023	09/113,222	ART39
PO8504	09/112,786	ART42
PO8000	09/113,051	ART43
PO7977	09/112,782	ART44
PO7934	09/113,056	ART45
PO7990	09/113,059	ART46
PO8499	09/113,091	ART47
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PO7981	09/113,055	ART50
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PO8072	09/112,787, PN 6213588	IJ02
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PO7941	09/113,110	IJM24
PO8077	09/113,112	IJM25
PO8058	09/113,087	IJM26
PO8051	09/113,074	IJM27
PO8045	6,110,754	IJM28

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CROSS-REFERENCED AUSTRALIAN PROVISTONAL PATENT APPLICATION NO.	U.S. Pat. No. /PATENT APPLICATION (CLAIMING RIGHT OF PRIORITY FROM AUSTRALIAN PROVISIONAL APPLICATION)	DOCKET NO.
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PO8046	09/112,771	IJM30
PO9390	09/112,769	IJM31
PO9392	09/112,770	IJM32
PP0889	09/112,798	IJM35
PP0887	09/112,801	IJM36
PP0882	09/112,800	IJM37
PP0874	09/112,799	IJM38
PP1396	09/113,098	IJM39
PP3989	09/112,833, PN 6228668	IJM40
PP2591	09/112,832, PN 6180427	IJM41
PP3990	09/112,831, PN 6171875	IJM42
PP3986	09/112,830	IJM43
PP3984	09/112,836, PN 6245247	IJM44
PP3982	09/112,835	IJM45
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PP0870	09/113,106	IR02
PP0869	09/113,105	IR04
PP0887	09/113,104	IR05
PP0885	09/112,810	IR06
PP0884	09/112,766	IR10
PP0886	09/113,085	IR12
PP0871	09/113,086	IR13
PP0876	09/113,094	IR14
PP0877	09/112,760	IR16
PP0878	09/112,773, PN 6196739	IR17
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PP0881	09/113,092	IR21
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PO8007	09/113,093	MEMS03
PO8008	09/113,062	MEMS04
PO8010	6,041,600	MEMS05
PO8011	09/113,082	MEMS06
PO7947	6,067,797	MEMS07
PO7944	09/113,080	MEMS09
PO7946	6,044,646	MEMS10
PO9393	09/113,065	MEMS11
PP0875	09/113,078	MEMS12
PP0894	09/113,075	MEMS13

STATEMENT REGARDING FEDERALLY SPONSORED RESEARCH OR DEVELOPMENT

Not applicable.

FIELD OF THE INVENTION

The present invention relates to the field of inkjet printers and discloses an inkjet printing system which includes a bend actuator incorporated with a paddle for the ejection of ink through an ink ejection nozzle. In particular, the present invention discloses a method of manufacturing an ink jet printhead.

BACKGROUND OF THE INVENTION

Many ink jet printing mechanisms are known. Unfortunately, in mass production techniques, the production of ink jet printheads is quite difficult. For example, often, the orifice or nozzle plate is fabricated separately from the ink supply and ink ejection mechanism and bonded to the mechanism at a later stage (Hewlett-Packard Journal, Vol. 36 no 5, pp33-37 (1985)). These separate material processing steps required in handling such precision devices often add a substantial expense in manufacturing.

Additionally, side shooting ink jet technologies (U.S. Pat. No. 4,899,181) are often used but again, this limits the

amount of mass production throughput given any particular capital investment.

⁴⁵ Additionally, more esoteric techniques are also often utilised. These can include electroforming of nickel stage (Hewlett-Packard Journal, Vol. 36 no 5, pp33-37 (1985)), electro-discharge machining, laser ablation (U.S. Pat. No. 5,208,604), micro-punching, etc.

⁵⁰ The utilisation of the above techniques is likely to add substantial expense to the mass production of ink jet print-heads and therefore add substantially to their final cost.

⁵⁵ It would therefore be desirable if an efficient system for the mass production of ink jet printheads could be developed.

SUMMARY OF THE INVENTION

It is an object of the present invention to provide for a ⁶⁰ method of manufacturing of an ink jet printhead for the ejection of ink on demand from a plurality of nozzles in an efficient manner.

In accordance with a first aspect of the present invention, there is provided a method of manufacture of an ink jet ⁶⁵ printhead wherein an array of nozzles are formed on a substrate utilising planar monolithic deposition, lithographic and etching processes.

Multiple ink jet printheads are preferably formed simultaneously on a single planar substrate. The substrate can be a silicon wafer.

The printheads are preferably formed utilising standard vlsi/ulsi processing. Integrated drive electronics are preferably formed on the same substrate. The integrated drive electronics can comprise a CMOS process.

Ink can be ejected from the substrate substantially normal to the substrate.

In accordance with a further aspect of the present invention, there is provided a method of manufacture of an ink jet printhead arrangement including a series of nozzle chambers, the method comprising the steps of: (a) providing an initial semiconductor wafer having an electrical circuitry layer formed thereon; (b) etching a series of slots in at least the circuitry layer to define a nozzle cavity inlet; (c) depositing and etching a first layer of magnetic flux material on the electrical circuitry layer to define a first magnetic plate; (d) depositing and etching an insulating layer on the first layer and the electrical circuitry layer, the etching including etching vias for a subsequent conductive layer; (e) depositing and etching a conductive layer in the form of a conductive coil conductively interconnected to the electrical circuitry layer; (f) depositing and etching a hydrophobic material layer in the region of the conductive coil; (g) depositing and etching a sacrificial material layer in the region of the first magnetic plate and the coil, the etching including defining a cavity for walls of a nozzle chamber; (h) depositing and etching a second layer of magnetic flux material over the sacrificial material so as to substantially enclose the conductive coil; (i) etching away the sacrificial material; (j) etching an ink supply channel through the wafer to be in fluid communication with the nozzle chamber.

The step (g) further comprises etching cavities defining a series of spring posts and the step (h) preferably includes forming a series of leaf springs interconnected with the first magnetic plate for resiliently biasing the magnetic plate in a first direction. The conductive layer can comprise substantially copper. The step (j) can comprise a through wafer etch from a back surface of the wafer.

The method can further include the step of depositing corrosion barriers over portions of the arrangement so as to reduce corrosion effects and the etching of layers preferably includes etching vias to allow for the electrical interconnection of portions of subsequent layers.

The magnetic flux material can comprise substantially a cobalt nickel iron alloy and the wafer can comprise a double sided polished CMOS wafer.

The steps are preferably also utilized to simultaneously separate the wafer into separate printheads.

BRIEF DESCRIPTION OF THE DRAWINGS

Notwithstanding any other forms which may fall within the scope of the present invention, preferred forms of the invention will now be described, by way of example only, with reference to the accompanying drawings in which:

FIG. 1 to FIG. 3 are schematic illustrations of the operation of an ink jet nozzle arrangement of an embodiment.

FIG. 4 illustrates a side perspective view, partly in section, of a single ink jet nozzle arrangement of an embodiment;

FIG. 5 provides a legend of the materials indicated in FIG. 6 to 21;

FIG. 6 shows a semiconductor wafer used in a method according to the invention;

FIG. 7 shows the wafer of FIG. 6 with the silicon of the wafer etched;

FIG. 8 shows the wafer of FIG. 7 having a mask exposed to define a fixed magnetic plate;

FIG. 9 shows the wafer of FIG. 8 electroplated with CoNiFe;

FIG. 10 shows the wafer of FIG. 9 stripped and etched;

FIG. 11 shows the wafer of FIG. 10 etched to define contact vias;

FIG. 12 shows the wafer of FIG. 11 with a resist exposed to define a coil;

FIG. 13 shows the wafer of FIG. 12 with the resist stripped and etched;

FIG. 14 shows the wafer of FIG. 13 with a sacrificial layer etched using a mask to define spring posts;

FIG. 15 shows the wafer of FIG. 14 with a resist exposed to define walls of a magnetic plunger and spring posts;

FIG. 16 shows the wafer of FIG. 15 with CoNiFe deposited thereon;

FIG. 17 shows the wafer of FIG. 16 with a resist exposed and developed with a mask to define a roof of the magnetic plunger;

FIG. 18 shows the wafer of FIG. 17 with CoNiFe deposited thereon;

FIG. 19 shows the wafer of FIG. 18 with the stripped resist, sacrificial and exposed seed layers;

FIG. 20 shows the wafer of FIG. 19 back etched to define ink inlets; and

FIG. 21 shows a nozzle arrangement for ink.

DESCRIPTION OF PREFERRED AND OTHER EMBODIMENTS

In the preferred embodiment, an ink jet printhead is fabricated to incorporate a series of nozzle arrangements where each nozzle arrangement includes an actuator having a magnetic plate or plunger which is actuated by a coil. The coil is pulsed to move the magnetic plunger which results in the ejection of ink. The movement of the magnetic plunger results in a leaf spring device being extended resiliently so that when the coil is deactivated, the magnetic plunger returns to a rest position. The movement of the magnetic plunger results in the ejection of a drop of ink from an aperture defined in the plunger.

Turning initially to FIG. 1, there is illustrated an ink jet nozzle arrangement 1 which includes a nozzle chamber 2 in communication with an ink ejection nozzle 3 so that, when in a quiescent or at rest position, an ink meniscus 4 extends from the nozzle 3. The nozzle 3 is formed in the magnetic plunger 5 which is constructed from a ferrous material and which incorporates walls of the nozzle chamber 2. Attached to the plunger 5 is a series of leaf springs 6, 7 which bias the plunger 5 away from a fixed magnetic plate 9. Between the plunger 5 and the plate 9, there is provided a conductive coil 10 which is interconnected with, and controlled by a lower circuitry layer 11 which can comprise a standard CMOS circuitry layer. The ink chamber 2 is supplied with ink from a lower ink supply channel 12 which is formed by etching through a wafer substrate 13. The wafer substrate 13 can comprise a semiconductor wafer substrate. The ink chamber 2 is interconnected to the ink supply channel 12 by means of a series of slots 14 which can be etched through the CMOS layer 11.

The area around the coil 10 is hydrophobically treated so that, during operation, a small meniscus 16, 17 forms between the plunger 5 and plate 9.

When a drop of ink is to be ejected, the coil 10 is energised. This results in a movement of the plunger 5 as

illustrated in FIG. 2. The general downward movement of the plunger 5 results in a substantial increase in pressure within the nozzle chamber 2. The increase in pressure results in a rapid growth in the meniscus 4 as ink flows out of the nozzle chamber 2. The movement of the plunger 5 also results in a general extension of the springs 6, 7. The small width of the slot 14 results in minimal outflows of ink into the nozzle chamber 2.

Moments later, as illustrated in FIG. 3, the coil 10 is deactivated, resulting in a return of the plunger 5 towards its quiescent position under action of the springs 6, 7 on the plunger 5. The return of the plunger 5 to its quiescent position results in a rapid decrease in pressure within the nozzle chamber 2 which in turn results in a general back flow of ink around the ejection nozzle 3. The forward momentum of the ink outside the plunger 5 and the back suction of the ink around the nozzle 3 results in a drop 19 being formed and breaking off to continue to the print media.

The surface tension characteristics across the nozzle 3 result in a general inflow of ink from the ink supply channel 12 until such time as the quiescent position of FIG. 1 is again reached. In this manner, a coil actuated magnetic ink jet printhead is formed for the provision of ink drops on demand. Importantly, the area around the coil 10 is hydrophobically treated to inhibit ink from flowing into this area.

Turning now to FIG. 4, there is illustrated a side perspective view, partly in section, of a single nozzle arrangement constructed in accordance with the principles as previously outlined with respect to FIG. 1 to FIG. 3. The nozzle plate 5 is formed around the ink supply chamber 2 and includes the ink ejection nozzle 3. A series of leaf spring elements 6-8 are also provided which can be formed from the same material as the nozzle plate 5. A base plate 9 is also provided for encompassing the coil 10. The wafer 13 includes a series of slots 14 for the wicking and flowing of ink into the nozzle chamber 2 with the nozzle chamber 2 being interconnected, via the slots 14, with an ink supply channel 12. The slots 14 are of a thin elongated form to provide for fluidic resistance to a rapid outflow of fluid from the chamber 2.

The coil 10 is conductively interconnected at a predetermined portion (not shown) with a lower CMOS layer for the control and driving of the coil 10 and movement of the base plate 5. Alternatively, the plate 9 is in the form of two separate semi-circular plates and the coil 10 can have separate ends connected through one of the semi circular plates through to a lower CMOS layer.

An array of ink jet nozzle arrangements can be formed at a time on a single silicon wafer.

One form of detailed manufacturing process which can be used to fabricate monolithic ink jet printheads operating in accordance with the principles taught by the present embodiment can proceed with the following steps:

1. Using a double sided polished wafer 13, complete a 0.5 micron, one poly, 2 metal CMOS process 11. Due to high current densities, both metal layers should be copper for resistance to electromigration. This step is shown in FIG. 6. For clarity, these diagrams may not be to scale, and may not represent a cross section though any single plane of the nozzle. FIG. 5 is a key to representations of various materials in these manufacturing diagrams, and those of other cross referenced ink jet configurations.
2. Etch the CMOS oxide layers down to silicon or aluminum using Mask 1. This mask defines a cruciform nozzle chamber inlet, defining the slots 14 edges of the printhead chips, and the vias for the contacts from

second level metal electrodes to the two halves of the split fixed magnetic plate 9.

3. Plasma etch the silicon to a depth of 15 microns, using oxide from step 2 as a mask. This etch does not substantially etch the second level metal. This step is shown in FIG. 7.
4. Deposit a seed layer of cobalt nickel iron alloy. CoNiFe is chosen due to a high saturation flux density of 2 Tesla, and a low coercivity. [Osaka, Tetsuya et al, A soft magnetic CoNiFe film with high saturation magnetic flux density, Nature 392, 796-798 (1998)].
5. Spin on 4 microns of resist 50, expose with Mask 2, and develop. This mask defines the split fixed magnetic plate 9, for which the resist acts as an electroplating mold. This step is shown in FIG. 8.
6. Electroplate 3 microns of CoNiFe. This step is shown in FIG. 9.
7. Strip the resist and etch the exposed seed layer. This step is shown in FIG. 10.
8. Deposit 0.5 microns of silicon nitride 51, which insulates the coil 10 from the fixed magnetic plate 9.
9. Etch the nitride layer using Mask 3. This mask defines the contact vias from each end of the solenoid coil to the two halves of the split fixed magnetic plate 9, as well as returning the nozzle chamber 2 to a hydrophilic state. This step is shown in FIG. 11.
10. Deposit an adhesion layer plus a copper seed layer. Copper is used for its low resistivity (which results in higher efficiency) and its high electromigration resistance, which increases reliability at high current densities.
11. Spin on 13 microns of resist 52 and expose using Mask 4, which defines the coil 10 in a spiral form. The resist acts as an electroplating mold for the coil 10. As the resist is thick and the aspect ratio is high, an X-ray proximity process, such as LIGA, can be used. This step is shown in FIG. 12.
12. Deposit 12 microns of copper 10 by electroplating.
13. Strip the resist and etch the exposed copper seed layer. This step is shown in FIG. 13.
14. Wafer probe. All electrical connections are complete at this point, bond pads are accessible, and the chips are not yet separated.
15. Deposit 0.1 microns of silicon nitride, which acts as a corrosion barrier (not shown).
16. Deposit 0.1 microns of PTFE (not shown), which makes the top surface of the fixed magnetic plate 9 and the coil 10 hydrophobic, thereby preventing the space between the coil 10 and the magnetic plate 5 from filling with ink (if a water based ink is used. In general, these surfaces should be made ink-phobic).
17. Etch the PTFE layer using Mask 5. This mask defines the hydrophilic region of the nozzle chamber 2. The etch returns the nozzle chamber 2 to a hydrophilic state.
18. Deposit 1 micron of sacrificial material 53. This defines a magnetic gap, and travel of the magnetic plate 5.
19. Etch the sacrificial layer using Mask 6. This mask defines spring posts. This step is shown in FIG. 14.
20. Deposit a seed layer of CoNiFe.
21. Deposit 12 microns of resist 54. As the solenoids will prevent even flow during a spin-on application, the resist should be sprayed on. Expose the resist using Mask 7, which defines the walls of the magnetic

plunger, plus the spring posts. As the resist is thick and the aspect ratio is high, an X-ray proximity process, such as LIGA, can be used. This step is shown in FIG. 15.

22. Deposit 12 microns of CoNiFe 55 by electroplating. This step is shown in FIG. 16.
23. Deposit a seed layer of CoNiFe.
24. Spin on 4 microns of resist 56, expose with Mask 8, and develop. This mask defines a roof of the magnetic plunger, the nozzle, the springs, and the spring posts. The resist forms an electroplating mold for these parts. This step is shown in FIG. 17.
25. Deposit 3 microns of CoNiFe 57 by electroplating. This step is shown in FIG. 18.
26. Strip the resist, sacrificial, and exposed seed layers. This step is shown in FIG. 19.
27. Back-etch through the silicon wafer until the nozzle chamber inlet slots 14 are reached using Mask 9. This etch may be performed using an ASE Advanced Silicon Etcher from Surface Technology Systems. The mask defines the ink inlets 12 which are etched through the wafer. The wafer is also diced by this etch. This step is shown in FIG. 20.
28. Mount the printheads in their packaging, which may be a molded plastic former incorporating ink channels which supply the appropriate color ink to the ink inlets at the back of the wafer.
29. Connect the printheads to their interconnect systems. For a low profile connection with minimum disruption of airflow, TAB may be used. Wire bonding may also be used if the printer is to be operated with sufficient clearance to the paper.
30. Fill the completed printhead with ink 58 and test them. A filled nozzle arrangement is shown in FIG. 21.

The presently disclosed ink jet printing technology is potentially suited to a wide range of printing system including: color and monochrome office printers, short run digital printers, high speed digital printers, offset press supplemental printers, low cost scanning printers high speed pagewidth printers, notebook computers with in-built pagewidth printers, portable color and monochrome printers, color and monochrome copiers, color and monochrome facsimile machines, combined printer, facsimile and copying machines, label printers, large format plotters, photograph copiers, printers for digital photographic "minilabs", video printers, PHOTO CD (PHOTO CD is a registered trade mark of Eastman Kodak Company) printers, portable printers for PDAs, wallpaper printers, indoor sign printers, billboard printers, fabric printers, camera printers and fault tolerant commercial printer arrays.

It would be appreciated by a person skilled in the art that numerous variations and/or modifications may be made to the present invention as shown in the specific embodiments without departing from the spirit or scope of the invention as broadly described. The present embodiments are, therefore, to be considered in all respects to be illustrative and not restrictive.

Ink Jet Technologies

The embodiments of the invention use an ink jet printer type device. Of course many different devices could be used. However presently popular ink jet printing technologies are unlikely to be suitable.

The most significant problem with thermal ink jet is power consumption. This is approximately 100 times that required for high speed, and stems from the energy-inefficient means of drop ejection. This involves the rapid

boiling of water to produce a vapor bubble which expels the ink. Water has a very high heat capacity, and must be superheated in thermal ink jet applications. This leads to an efficiency of around 0.02%, from electricity input to drop momentum (and increased surface area) out.

The most significant problem with piezoelectric ink jet is size and cost. Piezoelectric crystals have a very small deflection at reasonable drive voltages, and therefore require a large area for each nozzle. Also, each piezoelectric actuator must be connected to its drive circuit on a separate substrate. This is not a significant problem at the current limit of around 300 nozzles per print head, but is a major impediment to the fabrication of pagewidth print heads with 19,200 nozzles.

Ideally, the ink jet technologies used meet the stringent requirements of in-camera digital color printing and other high quality, high speed, low cost printing applications. To meet the requirements of digital photography, new ink jet technologies have been created. The target features include:

- 20 low power (less than 10 Watts)
- high resolution capability (1,600 dpi or more)
- photographic quality output
- low manufacturing cost
- small size (pagewidth times minimum cross section)
- high speed (<2 seconds per page).

All of these features can be met or exceeded by the ink jet systems described below with differing levels of difficulty. Forty-five different ink jet technologies have been developed by the Assignee to give a wide range of choices for high volume manufacture. These technologies form part of separate applications assigned to the present Assignee as set out in the list under the heading Cross References to Related Applications.

The ink jet designs shown here are suitable for a wide range of digital printing systems, from battery powered one-time use digital cameras, through to desktop and network printers, and through to commercial printing systems.

For ease of manufacture using standard process equipment, the print head is designed to be a monolithic 0.5 micron CMOS chip with MEMS post processing. For color photographic applications, the print head is 100 mm long, with a width which depends upon the ink jet type. The smallest print head designed is covered in U.S. patent application Ser. No. 09/112,764, which is 0.35 mm wide, giving a chip area of 35 square mm. The print heads each contain 19,200 nozzles plus data and control circuitry.

Ink is supplied to the back of the print head by injection molded plastic ink channels. The molding requires 50 micron features, which can be created using a lithographically micromachined insert in a standard injection molding tool. Ink flows through holes etched through the wafer to the nozzle chambers fabricated on the front surface of the wafer. The print head is connected to the camera circuitry by tape automated bonding.

Tables of Drop-on-Demand Ink Jets

Eleven important characteristics of the fundamental operation of individual ink jet nozzles have been identified. These characteristics are largely orthogonal, and so can be elucidated as an eleven dimensional matrix. Most of the eleven axes of this matrix include entries developed by the present assignee.

The following tables form the axes of an eleven dimensional table of ink jet types.

- 65 Actuator mechanism (18 types)
- Basic operation mode (7 types)
- Auxiliary mechanism (8 types)

Actuator amplification or modification method (17 types)
 Actuator motion (19 types)
 Nozzle refill method (4 types)
 Method of restricting back-flow through inlet (10 types)
 Nozzle clearing method (9 types)
 Nozzle plate construction (9 types)
 Drop ejection direction (5 types)
 Ink type (7 types)

The complete eleven dimensional table represented by these axes contains 36.9 billion possible configurations of ink jet nozzle. While not all of the possible combinations result in a viable ink jet technology, many million configurations are viable. It is clearly impractical to elucidate all of the possible configurations. Instead, certain ink jet types have been investigated in detail. Forty-five such inkjet types were filed simultaneously to the present application.

Other ink jet configurations can readily be derived from these forty-five examples by substituting alternative configurations along one or more of the 11 axes. Most of the

forty-five examples can be made into ink jet print heads with characteristics superior to any currently available ink jet technology.

Where there are prior art examples known to the inventor, one or more of these examples are listed in the examples column of the tables below. The simultaneously filed patent applications by the present applicant are listed by USSN numbers. In some cases, a print technology may be listed 5 more than once in a table, where it shares characteristics with more than one entry.

Suitable applications for the ink jet technologies include: Home printers, Office network printers, Short run digital printers, Commercial print systems, Fabric printers, Pocket 15 printers, Internet WWW printers, Video printers, Medical imaging, Wide format printers, Notebook PC printers, Fax machines, Industrial printing systems, Photocopiers, Photographic minilabs etc.

The information associated with the aforementioned 11 dimensional matrix are set out in the following tables.

ACTUATOR MECHANISM (APPLIED ONLY TO SELECTED INK DROPS)

	Description	Advantages	Disadvantages	Examples
Thermal bubble	An electrothermal heater heats the ink to above boiling point, transferring significant heat to the aqueous ink. A bubble nucleates and quickly forms, expelling the ink. The efficiency of the process is low, with typically less than 0.05% of the electrical energy being transformed into kinetic energy of the drop.	Large force generated Simple construction No moving parts Fast operation Small chip area required for actuator	High power Ink carrier limited to water Low efficiency High temperatures required High mechanical stress Unusual materials required Large drive transistors Cavitation causes actuator failure Kogation reduces bubble formation Large print heads are difficult to fabricate	Canon Bubblejet 1979 Endo et al GB patent 2,007,162 Xerox heater-in-pit 1990 Hawkins et al U.S. Pat. No. 4,899,181 Hewlett-Packard TIJ 1982 Vaught et al U.S. Pat. No. 4,490,728
Piezo-electric	A piezoelectric crystal such as lead lanthanum zirconate (PZT) is electrically activated, and either expands, shears, or bends to apply pressure to the ink, ejecting drops.	Low power consumption Many ink types can be used Fast operation High efficiency	Very large area required for actuator Difficult to integrate with electronics High voltage drive transistors required Full pagewidth print heads impractical due to actuator size Requires electrical poling in high field strengths during manufacture	Kyser et al U.S. Pat. No. 3,946,398 Zoltan U.S. Pat. No. 3,683,212 1973 Stemme U.S. Pat. No. 3,747,120 Epson Stylus Tektronix IJ04
Electrostrictive	An electric field is used to activate electrostriction in relaxor materials such as lead lanthanum zirconate titanate (PLZT) or lead magnesium niobate (PMN).	Low power consumption Many ink types can be used Low thermal expansion Electric field strength required (approx. 3.5 V/ μ m) can be generated without difficulty Does not require	Low maximum strain (approx. 0.01%) Large area required for actuator due to low strain Response speed is marginal (~10 μ s) High voltage drive transistors required	Seiko Epson, Usui et al JP 253401/96 IJ04

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ACTUATOR MECHANISM (APPLIED ONLY TO SELECTED INK DROPS)

Description	Advantages	Disadvantages	Examples	
Ferro-electric	An electric field is used to induce a phase transition between the antiferroelectric (AFEY) and ferroelectric (FE) phase. Perovskite materials such as tin modified lead lanthanum zirconate titanate (PLZSnT) exhibit large strains of upto 1% associated with the AFE to FE phase transition.	electrical poling Low power consumption Many ink types can be used Fast operation (<1 μ s) Relatively high longitudinal strain High efficiency Electric field strength of around 3 V/ μ m can be readily provided	Full pagewidth print heads impractical due to actuator size Difficult to integrate with electronics Unusual materials such as PLZSnT are required Actuators require a large area	IJ04
Electro-static plates	Conductive plates are separated by a compressible or fluid dielectric (usually air) Upon application of a voltage, the plates attract each other and displace ink, causing drop ejection. The conductive plates may be in a comb or honeycomb structure, or stacked to increase the surface area and therefore the force.	Low power consumption Many ink types can be used Fast operation	Difficult to operate electrostatic devices in an aqueous environment The electrostatic actuator will normally need to be separated from the ink Very large area required to achieve high forces High voltage drive transistors may be required Full pagewidth print heads are not competitive due to actuator size	IJ02, IJ04
Electro-static pull on ink	A strong electric field is applied to the ink, whereupon electrostatic attraction accelerates the ink towards the print medium.	Low current consumption Low temperature	High voltage required May be damaged by sparks due to air breakdown Required field strength increases as the drop size decreases High voltage drive transistors required Electrostatic field attracts dust	1989 Saito et al, U.S. Pat. No. 4,799,068 1989 Miura et al, U.S. Pat. No. 4,810,954 Tone-jet
Permanent magnet electro-magnetic	An electromagnet directly attracts a permanent magnet, displacing ink and causing drop ejection. Rare earth magnets with a field strength around 1 Tesla can be used. Examples are: Samarium Cobalt (SaCo) and magnetic materials in the neodymium iron boron family (NdFeB), NdDyFeBNb, NdDyFeB, etc)	Low power consumption Many ink types can be used Fast operation High efficiency Easy extension from single nozzles to pagewidth print heads	Complex fabrication Permanent magnetic material such as Neodymium Iron Boron (NdFeB) required. High local currents required Copper metallization should be used for long electromigration lifetime and low resistivity Pigmented inks are usually infeasible Operating temperature limited to the Curie temperature (around 540 K)	IJ07, IJ10

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ACTUATOR MECHANISM (APPLIED ONLY TO SELECTED INK DROPS)

	Description	Advantages	Disadvantages	Examples
Soft magnetic core electro-magnetic	A solenoid induced a magnetic field in a soft magnetic core or yoke fabricated from a ferrous material such as electroplated iron alloys such as CoNiFe [1], CoFe, or NiFe alloys. Typically, the soft magnetic material is in two parts, which are normally held apart by a spring. When the solenoid is actuated, the two parts attract, displacing the ink.	Low power consumption Many ink types can be used Fast operation High efficiency Easy extension from single nozzles to pagewidth print heads	Complex fabrication Materials not usually present in a CMOS fab such as NiFe, CoNiFe, or CoFe are required High local currents required Copper metallization should be used for long electromigration lifetime and low resistivity Electroplating is required High saturation flux density is required (2.0–2.1 T is achievable with CoNiFe [1])	IJ01, IJ05, IJ08, IJ10, IJ12, IJ14, IJ15, IJ17
Lorenz force	The Lorenz force acting on a current carrying wire in a magnetic field is utilized. This allows the magnetic field to be supplied externally to the print head, for example with rare earth permanent magnets. Only the current carrying wire need be fabricated on the print-head, simplifying materials requirements.	Low power consumption Many ink types can be used Fast operation High efficiency Easy extension from single nozzles to pagewidth print heads	Force acts as a twisting motion Typically, only a quarter of the solenoid length provides force in a useful direction High local currents required Copper metallization should be used for long electromigration lifetime and low resistivity Pigmented inks are usually infeasible	IJ06, IJ11, IJ13, IJ16
Magneto-striction	The actuator uses the giant magnetostrictive effect of materials such as Terfenol-D (an alloy of terbium, dysprosium and iron developed at the Naval Ordnance Laboratory, hence Ter-Fe-NOL). For best efficiency, the actuator should be pre-stressed to approx. 8 MPa.	Many ink types can be used Fast operation Easy extension from single nozzles to pagewidth print heads High force is available	Force acts as a twisting motion Unusual materials such as Terfenol-D are required High local currents required Copper metallization should be used for long electromigration lifetime and low resistivity Pre-stressing may be required	Fischenbeck, U.S. Pat. No. 4,032,929 IJ25
Surface tension reduction	Ink under positive pressure is held in a nozzle by surface tension. The surface tension of the ink is reduced below the bubble threshold, causing the ink to egress from the nozzle.	Low power consumption Simple construction No unusual materials required in fabrication High efficiency Easy extension from single nozzles to pagewidth print heads	Requires supplementary force to effect drop separation Requires special ink surfactants Speed may be limited by surfactant properties	Silverbrook, EP 0771 658 A2 and related patent applications
Viscosity reduction	The ink viscosity is locally reduced to select which drops are to be ejected. A viscosity reduction can be achieved electrothermally with	Simple construction No unusual materials required in fabrication Easy extension from single nozzles	Requires supplementary force to effect drop separation Requires special ink viscosity properties	Silverbrook, EP 0771 658 A2 and related patent applications

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ACTUATOR MECHANISM (APPLIED ONLY TO SELECTED INK DROPS)

Description	Advantages	Disadvantages	Examples
most inks, but special inks can be engineered for a 100:1 viscosity reduction.	to pagewidth print heads	High speed is difficult to achieve Requires oscillating ink pressure A high temperature difference (typically 80 degrees) is required	
Acoustic	An acoustic wave is generated and focussed upon the drop ejection region.	Can operate without a nozzle plate	Complex drive circuitry Complex fabrication Low efficiency Poor control of drop position Poor control of drop volume
Thermo-elastic bend actuator	An actuator which relies upon differential thermal expansion upon Joule heating is used.	Low power consumption Many ink types can be used Simple planar fabrication Small chip area required for each actuator Fast operation High efficiency CMOS compatible voltages and currents Standard MEMS processes can be used Easy extension from single nozzles to pagewidth print heads	Efficient aqueous operation requires a thermal insulator on the hot side Corrosion prevention can be difficult Pigmented inks may be infeasible, as pigment particles may jam the bend actuator
High CTE thermo elastic actuator	A material with a very high coefficient of thermal expansion (CTE) such as polytetrafluoroethylene (PTFE) is used. As high CTE materials are usually non-conductive, a heater fabricated from a conductive material is incorporated. A 50 μ m long PTFE bend actuator with polysilicon heater and 15 mW power input can provide 180 μ N force and 10 μ m deflection. Actuator motions include: Bend Push Buckle Rotate	High force can be generated Three methods of PTFE deposition are under development: chemical vapor deposition (CVD), spin coating, and evaporation PTFE is a candidate for low dielectric constant insulation in ULSI Very low power consumption Many ink types can be used Simple planar fabrication Small chip area required for each actuator Fast operation High efficiency CMOS compatible voltages and currents Easy extension from single nozzles to pagewidth print heads	IJ03, IJ09, IJ17, IJ18, IJ19, IJ20, IJ21, IJ22, IJ23, IJ24, IJ27, IJ28, IJ29, IJ30, IJ31, IJ32, IJ33, IJ34, IJ35, IJ36, IJ37, IJ38, IJ39, IJ40, IJ41
Conductive polymer thermo-elastic	A polymer with a high coefficient of thermal expansion (such as PTFE) is doped with	Requires special material (e.g. PTFE) Requires a PTFE deposition process, which is not yet standard in ULSI fabs PTFE deposition cannot be followed with high temperature (above 350° C.) processing Pigmented inks may be infeasible, as pigment particles may jam the bend actuator	IJ09, IJ17, IJ18, IJ20, IJ21, IJ22, IJ23, IJ24, IJ27, 1328, IJ29, IJ30, IJ31, IJ42, IJ43, IJ44
		High force can be generated Very low power consumption	IJ24

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ACTUATOR MECHANISM (APPLIED ONLY TO SELECTED INK DROPS)

	Description	Advantages	Disadvantages	Examples
actuator	<p>conducting substances to increase its conductivity to about 3 orders of magnitude below that of copper. The conducting polymer expands when resistively heated. Examples of conducting dopants include:</p> <ul style="list-style-type: none"> Carbon nanotubes Metal fibers Conductive polymers such as doped polythiophene Carbon granules 	<p>Many ink types can be used</p> <p>Simple planar fabrication</p> <p>Small chip area required for each actuator</p> <p>Fast operation</p> <p>High efficiency</p> <p>CMOS compatible voltages and currents</p> <p>Easy extension from single nozzles to pagewidth print heads</p>	<p>(polymer)</p> <p>Requires a PTFE deposition process, which is not yet standard in ULSI fabs</p> <p>PTFE deposition cannot be followed with high temperature (above 350° C.) processing</p> <p>Evaporation and CVD deposition techniques cannot be used</p> <p>Pigmented inks may be infeasible, as pigment particles may jam the bend actuator</p>	
Shape memory alloy	<p>A shape memory alloy such as TiNi (also known as Nitinol - Nickel Titanium alloy developed at the Naval Ordnance Laboratory) is thermally switched between its weak martensitic state and its high stiffness austenitic state. The shape of the actuator in its martensitic state is deformed relative to the austenitic shape. The shape change causes ejection of a drop.</p>	<p>High force is available (stresses of hundreds of MPa)</p> <p>Large strain is available (more than 3%)</p> <p>High corrosion resistance</p> <p>Simple construction</p> <p>Easy extension from single nozzles to pagewidth print heads</p> <p>Low voltage operation</p>	<p>Fatigue limits maximum number of cycles</p> <p>Low strain (1%) is required to extend fatigue resistance</p> <p>Cycle rate limited by heat removal</p> <p>Requires unusual materials (TiNi)</p> <p>The latent heat of transformation must be provided</p> <p>High current operation</p> <p>Requires pre-stressing to distort the martensitic state</p>	IJ26
Linear Magnetic Actuator	<p>Linear magnetic actuators include the Linear Induction Actuator (LIA), Linear Permanent Magnet Synchronous Actuator (LPMSA), Linear Reluctance Synchronous Actuator (LRSA), Linear Switched Reluctance Actuator (LSRA), and the Linear Stepper Actuator (LSA).</p>	<p>Linear Magnetic actuators can be constructed with high thrust, long travel, and high efficiency using planar semiconductor fabrication techniques</p> <p>Long actuator travel is available</p> <p>Medium force is available</p> <p>Low voltage operation</p>	<p>Requires unusual semiconductor materials such as soft magnetic alloys (e.g. CoNiFe)</p> <p>Some varieties also require permanent magnetic materials such as Neodymium iron boron (NdFeB)</p> <p>Requires complex multi-phase drive circuitry</p> <p>High current operation</p>	IJ12

BASIC OPERATION MODE

	Description	Advantages	Disadvantages	Examples
Actuator directly pushes ink	<p>This is the simplest mode of operation: the actuator directly supplies sufficient kinetic energy to expel the drop. The drop must have a sufficient velocity to overcome the surface tension.</p>	<p>Simple operation</p> <p>No external fields required</p> <p>Satellite drops can be avoided if drop velocity is less than 4 m/s</p> <p>Can be efficient, depending upon the actuator used</p>	<p>Drop repetition rate is usually limited to around 10 kHz. However, this is not fundamental to the method, but is related to the refill method normally used</p> <p>All of the drop</p>	<p>Thermal ink jet</p> <p>Piezoelectric ink jet</p> <p>IJ01, IJ02, IJ03, IJ04, IJ05, IJ06, IJ07, IJ09, IJ11, IJ12, IJ14, IJ16, IJ20, IJ22, IJ23, IJ24, IJ25, IJ26, IJ27, IJ28, IJ29,</p>

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BASIC OPERATION MODE

Description	Advantages	Disadvantages	Examples	
Proximity	The drops to be printed are selected by some manner (e.g. thermally induced surface tension reduction of pressurized ink). Selected drops are separated from the ink in the nozzle by contact with the print medium or a transfer roller.	Very simple print head fabrication can be used The drop selection means does not need to provide the energy required to separate the drop from the nozzle	kinetic energy must be provided by the actuator Satellite drops usually form if drop velocity is greater than 4.5 mls Requires close proximity between the print head and the print media or transfer roller May require two print heads printing alternate rows of the image Monolithic color print heads are difficult	II30, II31, II32, II33, II34, II35, II36, II37, II38, II39, II40, II41, II42, II43, II44 Silverbrook, EP 0771 658 A2 and related patent applications
Electrostatic pull on ink	The drops to be printed are selected by some manner (e.g. thermally induced surface tension reduction of pressurized ink). Selected drops are separated from the ink in the nozzle by a strong electric field.	Very simple print head fabrication can be used The drop selection means does not need to provide the energy required to separate the drop from the nozzle	Requires very high electrostatic field Electrostatic field for small nozzle sizes is above air breakdown Electrostatic field may attract dust	Silverbrook, EP 0771 658 A2 and related patent applications Tone-Jet
Magnetic pull on ink	The drops to be printed are selected by some manner (e.g. thermally induced surface tension reduction of pressurized ink). Selected drops are separated from the ink in the nozzle by a strong magnetic field acting on the magnetic ink.	Very simple print head fabrication can be used The drop selection means does not need to provide the energy required to separate the drop from the nozzle	Requires magnetic ink Ink colors other than black are difficult Requires very high magnetic fields	Silverbrook, EP 0771 658 A2 and related patent applications
Shutter	The actuator moves a shutter to block ink flow to the nozzle. The ink pressure is pulsed at a multiple of the drop ejection frequency.	High speed (>50 kHz) operation can be achieved due to reduced refill time Drop timing can be very accurate The actuator energy can be very low	Moving parts are required Requires ink pressure modulator Friction and wear must be considered Stiction is possible	II13, II17, II21
Shuttered grill	The actuator moves a shutter to block ink flow through a grill to the nozzle. The shutter movement need only be equal to the width of the grill holes.	Actuators with small travel can be used Actuators with small force can be used High speed (>50 kHz) operation can be achieved	Moving parts are required Requires ink pressure modulator Friction and wear must be considered Stiction is possible	II08, II15, II18, II19
Pulsed magnetic pull on ink pusher	A pulsed magnetic field attracts an 'ink pusher' at the drop ejection frequency. An actuator controls a catch, which prevents the ink pusher from moving when a drop is not to be ejected.	Extremely low energy operation is possible No heat dissipation problems	Requires an external pulsed magnetic field Requires special materials for both the actuator and the ink pusher Complex construction	II10

AUXILIARY MECHANISM (APPLIED TO ALL NOZZLES)

	Description	Advantages	Disadvantages	Examples
None	The actuator directly fires the ink drop, and there is no external field or other mechanism required.	Simplicity of construction Simplicity of operation Small physical size	Drop ejection energy must be supplied by individual nozzle actuator	Most ink jets, including piezoelectric and thermal bubble. IJ01, IJ02, IJ03, IJ04, IJ05, IJ07, IJ09, IJ11, IJ12, IJ14, IJ20, IJ22, IJ23, IJ24, IJ25, IJ26, IJ27, IJ28, IJ29, IJ30, IJ31, IJ32, IJ33, IJ34, IJ35, IJ36, IJ37, IJ38, IJ39, IJ40, IJ41, IJ42, IJ43, IJ44
Oscillating ink pressure (including acoustic stimulation)	The ink pressure oscillates, providing much of the drop ejection energy. The actuator selects which drops are to be fired by selectively blocking or enabling nozzles. The ink pressure oscillation may be achieved by vibrating the print head, or preferably by an actuator in the ink supply.	Oscillating ink pressure can provide a refill pulse, allowing higher operating speed The actuators may operate with much lower energy Acoustic lenses can be used to focus the sound on the nozzles	Requires external ink pressure oscillator Ink pressure phase and amplitude must be carefully controlled Acoustic reflections in the ink chamber must be designed for	Silverbrook, EP 0771 658 A2 and related patent applications IJ08, IJ13, IJ15, IJ17, 1318, IJ19, IJ21
Media proximity	The print head is placed in close proximity to the print medium. Selected drops protrude from the print head further than unselected drops, and contact the print medium. The drop soaks into the medium fast enough to cause drop separation.	Low power High accuracy Simple print head construction	Precision assembly required Paper fibers may cause problems Cannot print on rough substrates	Silverbrook, EP 0771 658 A2 and related patent applications
Transfer roller	Drops are printed to a transfer roller instead of straight to the print medium. A transfer roller can also be used for proximity drop separation.	High accuracy Wide range of print substrates can be used Ink can be dried on the transfer roller	Bulky Expensive Complex construction	Silverbrook, EP 0771 658 A2 and related patent applications Tektronix hot melt piezoelectric ink jet Any of the IJ series
Electrostatic	An electric field is used to accelerate selected drops towards the print medium.	Low power Simple print head construction	Field strength required for separation of small drops is near or above air breakdown	Silverbrook, EP 0771 658 A2 and related patent applications Tone-Jet
Direct magnetic field	A magnetic field is used to accelerate selected drops of magnetic ink towards the print medium.	Low power Simple print head construction	Requires magnetic ink Requires strong magnetic field	Silverbrook, EP 0771 658 A2 and related patent applications
Cross magnetic field	The print head is placed in a constant magnetic field. The Lorenz force in a current carrying wire is used to move the actuator.	Does not require magnetic materials to be integrated in the print head manufacturing process	Requires external magnet Current densities may be high, resulting in electromigration problems	IJ06, IJ16
Pulsed magnetic field	A pulsed magnetic field is used to cyclically attract a paddle, which pushes on the ink. A small	Very low power operation is possible Small print head size	Complex print head construction Magnetic materials required in print head	IJ10

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AUXILIARY MECHANISM (APPLIED TO ALL NOZZLES)

Description	Advantages	Disadvantages	Examples
actuator moves a catch, which selectively prevents the paddle from moving.			

ACTUATOR AMPLIFICATION OR MODIFICATION METHOD

	Description	Advantages	Disadvantages	Examples
None	No actuator mechanical amplification is used. The actuator directly drives the drop ejection process.	Operational simplicity	Many actuator mechanisms have insufficient travel, or insufficient force, to efficiently drive the drop ejection process	Thermal Bubble Ink jet IJ01, IJ02, IJ06, IJ07, IJ16, IJ25, IJ26
Differential expansion bend actuator	An actuator material expands more on one side than on the other. The expansion may be thermal, piezoelectric, magnetostrictive, or other mechanism. The bend actuator converts a high force low travel actuator mechanism to high travel, lower force mechanism.	Provides greater travel in a reduced print head area	High stresses are involved Care must be taken that the materials do not delaminate Residual bend resulting from high temperature or high stress during formation	Piezoelectric IJ03, IJ09, IJ17, IJ18, IJ19, IJ20, IJ21, IJ22, IJ23, IJ24, IJ27, IJ29, IJ30, IJ31, IJ32, IJ33, IJ34, IJ35, IJ36, IJ37, IJ38, IJ39, IJ42, IJ43, IJ44
Transient bend actuator	A trilayer bend actuator where the two outside layers are identical. This cancels bend due to ambient temperature and residual stress. The actuator only responds to transient heating of one side or the other.	Very good temperature stability High speed, as a new drop can be fired before heat dissipates Cancels residual stress of formation	High stresses are involved Care must be taken that the materials do not delaminate	IJ40, IJ41
Reverse spring	The actuator loads a spring. When the actuator is turned off, the spring releases. This can reverse the force/distance curve of the actuator to make it compatible with the force/time requirements of the drop ejection.	Better coupling to the ink	Fabrication complexity High stress in the spring	IJ05, IJ11
Actuator stack	A series of thin actuators are stacked. This can be appropriate where actuators require high electric field strength, such as electrostatic and piezoelectric actuators.	Increased travel Reduced drive voltage	Increased fabrication complexity Increased possibility of short circuits due to pinholes	Some piezoelectric ink jets IJ04
Multiple actuators	Multiple smaller actuators are used simultaneously to move the ink. Each actuator need provide only a portion of the force required.	Increases the force available from an actuator Multiple actuators can be positioned to control ink flow accurately	Actuator forces may not add linearly, reducing efficiency	IJ12, IJ13, IJ18, IJ20, IJ22, IJ28, IJ42, IJ43
Linear Spring	A linear spring is used to transform a motion with small travel and high force into a	Matches low travel actuator with higher travel requirements	Requires print head area for the spring	IJ15

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ACTUATOR AMPLIFICATION OR MODIFICATION METHOD

	Description	Advantages	Disadvantages	Examples
Coiled actuator	longer travel, lower force motion. A bend actuator is coiled to provide greater travel in a reduced chip area.	Non-contact method of motion transformation Increases travel Reduces chip area Planar implementations are relatively easy to fabricate.	Generally restricted to planar implementations due to extreme fabrication difficulty in other orientations.	IJ17, IJ21, IJ34, IJ35
Flexure bend actuator	A bend actuator has a small region near the fixture point, which flexes much more readily than the remainder of the actuator. The actuator flexing is effectively converted from an even coiling to an angular bend, resulting in greater travel of the actuator tip.	Simple means of increasing travel of a bend actuator	Care must be taken not to exceed the elastic limit in the flexure area Stress distribution is very uneven Difficult to accurately model with finite element analysis	IJ10, IJ19, IJ33
Catch	The actuator controls a small catch. The catch either enables or disables movement of an ink pusher that is controlled in a bulk manner.	Very low actuator energy Very small actuator size	Complex construction Requires external force Unsuitable for pigmented inks	IJ10
Gears	Gears can be used to increase travel at the expense of duration. Circular gears, rack and pinion, ratchets, and other gearing methods can be used.	Low force, low travel actuators can be used Can be fabricated using standard surface MEMS processes	Moving parts are required Several actuator cycles are required More complex drive electronics Complex construction Friction, friction, and wear are possible	IJ13
Buckle plate	A buckle plate can be used to change a slow actuator into a fast motion. It can also convert a high force, low travel actuator into a high travel, medium force motion.	Very fast movement achievable	Must stay within elastic limits of the materials for long device life High stresses involved Generally high power requirement	S. Hirata et al, "An Ink-jet Head Using Diaphragm Microactuator", Proc. IEEE MEMS, Feb. 1996, pp 418-423, IJ18, IJ27
Tapered magnetic pole	A tapered magnetic pole can increase travel at the expense of force.	Linearizes the magnetic force/distance curve	Complex construction	IJ14
Lever	A lever and fulcrum is used to transform a motion with small travel and high force into a motion with longer travel and lower force. The lever can also reverse the direction of travel.	Matches low travel actuator with higher travel requirements Fulcrum area has no linear movement, and can be used for a fluid seal	High stress around the fulcrum	IJ32, IJ36, IJ37
Rotary impeller	The actuator is connected to a rotary impeller. A small angular deflection of the actuator results in a rotation of the impeller vanes, which push the ink against stationary vanes and out of the nozzle.	High mechanical advantage The ratio of force to travel of the actuator can be matched to the nozzle requirements by varying the number of impeller vanes	Complex construction Unsuitable for pigmented inks	IJ28
Acoustic lens	A refractive or diffractive (e.g. zone plate) acoustic lens is	No moving parts	Large area required Only relevant for	1993 Hadimioglu et al, EUP 550,192 1993 Elrod et al,

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ACTUATOR AMPLIFICATION OR MODIFICATION METHOD

	Description	Advantages	Disadvantages	Examples
Sharp conductive point	used to concentrate sound waves. A sharp point is used to concentrate an electrostatic field.	Simple construction	acoustic ink jets Difficult to fabricate using standard VLSI processes for a surface ejecting ink-jet Only relevant for electrostatic ink jets	EUP 572,220 Tone-jet

ACTUATOR MOTION

	Description	Advantages	Disadvantages	Examples
Volume expansion	The volume of the actuator changes, pushing the ink in all directions.	Simple construction in the case of thermal ink jet	High energy is typically required to achieve volume expansion. This leads to thermal stress, cavitation, and kogation in thermal ink jet implementations High fabrication complexity may be required to achieve perpendicular motion	Hewlett-Packard Thermal Ink jet Canon Bubblejet
Linear, normal to chip surface	The actuator moves in a direction normal to the print head surface. The nozzle is typically in the line of movement.	Efficient coupling to ink drops ejected normal to the surface	Fabrication complexity Friction Stiction	IJ01, IJ02, IJ04, IJ07, IJ11, IJ14
Parallel to chip surface	The actuator moves parallel to the print head surface. Drop ejection may still be normal to the surface.	Suitable for planar fabrication	Fabrication complexity Friction Stiction	IJ12, IJ13, IJ15, IJ33, IJ34, IJ35, IJ36
Membrane push	An actuator with a high force but small area is used to push a stiff membrane that is in contact with the ink.	The effective area of the actuator becomes the membrane area	Fabrication complexity Actuator size Difficulty of integration in a VLSI process	1982 Howkins U.S. Pat. No. 4,459,601
Rotary	The actuator causes the rotation of some element, such a grill or impeller	Rotary levers may be used to increase travel Small chip area requirements	Device complexity May have friction at a pivot point	IJ05, IJ08, IJ13, IJ28
Bend	The actuator bends when energized. This may be due to differential thermal expansion, piezoelectric expansion, magnetostriction, or other form of relative dimensional change.	A very small change in dimensions can be converted to a large motion.	Requires the actuator to be made from at least two distinct layers, or to have a thermal difference across the actuator	1970 Kyser et al U.S. Pat. No. 3,946,398 1973 Stemme U.S. Pat. No. 3,747,120 IJ03, IJ09, IJ10, IJ19, IJ23, IJ24, IJ25, IJ29, IJ30, IJ31, IJ33, IJ34, IJ35
Swivel	The actuator swivels around a central pivot. This motion is suitable where there are opposite forces applied to opposite sides of the paddle, e.g. Lorenz force.	Allows operation where the net linear force on the paddle is zero Small chip area requirements	Inefficient coupling to the ink motion	IJ06
Straighten	The actuator is normally bent, and straightens when energized.	Can be used with shape memory alloys where the austenitic phase is planar	Requires careful balance of stresses to ensure that the quiescent bend is accurate	IJ26, IJ32
Double	The actuator bends in	One actuator can	Difficult to make	IJ36, IJ37, IJ38

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<u>ACTUATOR MOTION</u>				
	Description	Advantages	Disadvantages	Examples
bend	one direction when one element is energized, and bends the other way when another element is energized.	be used to power two nozzles. Reduced chip size. Not sensitive to ambient temperature	the drops ejected by both bend directions identical. A small efficiency loss compared to equivalent single bend actuators.	
Shear	Energizing the actuator causes a shear motion in the actuator material.	Can increase the effective travel of piezoelectric actuators	Not readily applicable to other actuator mechanisms	1985 Fishbeck U.S. Pat. No. 4,584,590
Radial constriction	The actuator squeezes an ink reservoir, forcing ink from a constricted nozzle.	Relatively easy to fabricate single nozzles from glass tubing as macroscopic structures	High force required Inefficient Difficult to integrate with VLSI processes	1970 Zoltan U.S. Pat. No. 3,683,212
Coil/uncoil	A coiled actuator uncoils or coils more tightly. The motion of the free end of the actuator ejects the ink.	Easy to fabricate as a planar VLSI process Small area required, therefore low cost	Difficult to fabricate for non-planar devices Poor out-of-plane stiffness	IJ17, IJ21, IJ34, IJ35
Bow	The actuator bows (or buckles) in the middle when energized.	Can increase the speed of travel Mechanically rigid	Maximum travel is constrained High force required	IJ16, IJ18, IJ27
Push-Pull	Two actuators control a shutter. One actuator pulls the shutter, and the other pushes it.	The structure is pinned at both ends, so has a high out-of-plane rigidity	Not readily suitable for ink jets which directly push the ink	IJ18
Curl inwards	A set of actuators curl inwards to reduce the volume of ink that they enclose.	Good fluid flow to the region behind the actuator increases efficiency	Design complexity	IJ20, IJ42
Curl outwards	A set of actuators curl outwards, pressurizing ink in a chamber surrounding the actuators, and expelling ink from a nozzle in the chamber.	Relatively simple construction	Relatively large chip area	IJ43
Iris	Multiple vanes enclose a volume of ink. These simultaneously rotate, reducing the volume between the vanes.	High efficiency Small chip area	High fabrication complexity Not suitable for pigmented inks	IJ22
Acoustic vibration	The actuator vibrates at a high frequency.	The actuator can be physically distant from the ink	Large area required for efficient operation at useful frequencies Acoustic coupling and crosstalk Complex drive circuitry Poor control of drop volume and position	1993 Hadimioglu et al, EUP 550,192 1993 Elrod et al, EUP 572,220
None	In various ink jet designs the actuator does not move.	No moving parts	Various other tradeoffs are required to eliminate moving parts	Silverbrook, EP 0771 658 A2 and related patent applications Tone-jet

NOZZLE REFILL METHOD

	Description	Advantages	Disadvantages	Examples
Surface tension	This is the normal way that ink jets are refilled. After the actuator is energized, it typically returns rapidly to its normal position. This rapid return sucks in air through the nozzle opening. The ink surface tension at the nozzle then exerts a small force restoring the meniscus to a minimum area. This force refills the nozzle.	Fabrication simplicity Operational simplicity	Low speed Surface tension force relatively small compared to actuator force Long refill time usually dominates the total repetition rate	Thermal ink jet Piezoelectric ink jet IJ01–IJ07, IJ10–IJ14, IJ16, IJ20, IJ22–IJ45
Shuttered oscillating ink pressure	Ink to the nozzle chamber is provided at a pressure that oscillates at twice the drop ejection frequency. When a drop is to be ejected, the shutter is opened for 3 half cycles: drop ejection, actuator return, and refill. The shutter is then closed to prevent the nozzle chamber emptying during the next negative pressure cycle.	High speed Low actuator energy, as the actuator need only open or close the shutter, instead of ejecting the ink drop	Requires common ink pressure oscillator May not be suitable for pigmented inks	IJ08, IJ13, IJ15, IJ17, IJ18, IJ19, IJ21
Refill actuator	After the main actuator has ejected a drop a second (refill) actuator is energized. The refill actuator pushes ink into the nozzle chamber. The refill actuator returns slowly, to prevent its return from emptying the chamber again.	High speed, as the nozzle is actively refilled	Requires two independent actuators per nozzle	IJ09
Positive ink pressure	The ink is held a slight positive pressure. After the ink drop is ejected, the nozzle chamber fills quickly as surface tension and ink pressure both operate to refill the nozzle.	High refill rate, therefore a high drop repetition rate is possible	Surface spill must be prevented Highly hydrophobic print head surfaces are required	Silverbrook, EP 0771 658 A2 and related patent applications Alternative for:, IJ01–IJ07, IJ10–IJ14, IJ16, IJ20, IJ22–IJ45

METHOD OF RESTRICTING BACK-FLOW THROUGH INLET

	Description	Advantages	Disadvantages	Examples
Long inlet channel	The ink inlet channel to the nozzle chamber is made long and relatively narrow, relying on viscous drag to reduce inlet back-flow.	Design simplicity Operational simplicity Reduces crosstalk	Restricts refill rate May result in a relatively large chip area Only partially effective	Thermal ink jet Piezoelectric ink jet IJ42, IJ43
Positive ink pressure	The ink is under a positive pressure, so that in the quiescent state some of the ink drop already protrudes	Drop selection and separation forces can be reduced Fast refill time	Requires a method (such as a nozzle rim or effective hydrophobizing, or	Silverbrook, EP 0771 658 A2 and related patent applications Possible

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METHOD OF RESTRICTING BACK-FLOW THROUGH INLET

Description	Advantages	Disadvantages	Examples
from the nozzle. This reduces the pressure in the nozzle chamber which is required to eject a certain volume of ink. The reduction in chamber pressure results in a reduction in ink pushed out through the inlet.		both) to prevent flooding of the ejection surface of the print head.	operation of the following: IJ01, II07, II09-II12, II14, II16, II20, II22, , II23-II34, II36-II41, II44
Baffle	One or more baffles are placed in the inlet ink flow. When the actuator is energized, the rapid ink movement creates eddies which restrict the flow through the inlet. The slower refill process is unrestricted, and does not result in eddies.	The refill rate is not as restricted as the long inlet method. Reduces crosstalk	Design complexity May increase fabrication complexity (e.g. Tektronix hot melt Piezoelectric print heads). HP Thermal Ink Jet Tektronix piezoelectric ink jet
Flexible flap restricts inlet	In this method recently disclosed by Canon, the expanding actuator (bubble) pushes on a flexible flap that restricts the inlet.	Significantly reduces back-flow for edge-shooter thermal ink jet devices	Canon
Inlet filter	A filter is located between the ink inlet and the nozzle chamber. The filter has a multitude of small holes or slots, restricting ink flow. The filter also removes particles which may block the nozzle.	Additional advantage of ink filtration Ink filter may be fabricated with no additional process steps	IJ04, II12, II24, II27, II29, II30
Small inlet compared to nozzle	The ink inlet channel to the nozzle chamber has a substantially smaller cross section than that of the nozzle resulting in easier ink egress out of the nozzle than out of the inlet.	Design simplicity	IJ02, II37, II44
Inlet shutter	A secondary actuator controls the position of a shutter, closing off the ink inlet when the main actuator is energized.	Increases speed of the ink-jet print head operation	IJ09
The inlet is located behind the ink-pushing surface	The method avoids the problem of inlet back-flow by arranging the ink-pushing surface of the actuator between the inlet and the nozzle.	Back-flow problem is eliminated	IJ01, IJ03, IJ05, IJ06, IJ07, IJ10, IJ11, IJ14, IJ16, IJ22, IJ23, IJ25, IJ28, IJ31, IJ32, IJ33, IJ34, IJ35, IJ36, IJ39, IJ40, IJ41
Part of the actuator moves to shut off the inlet	The actuator and a wall of the ink chamber are arranged so that the motion of the actuator closes off the inlet.	Significant reductions in back-flow can be achieved Compact designs possible	IJ07, II20, II26, II38
Nozzle actuator	In some configurations of ink jet, there is no	Ink back-flow problem is	Silverbrook, EP 0771 658 A2 and

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METHOD OF RESTRICTING BACK-FLOW THROUGH INLET

	Description	Advantages	Disadvantages	Examples
does not result in ink back-flow	expansion or movement of an actuator which may cause ink back-flow through the inlet.	eliminated	actuation	related patent applications Valve-jet Tone-jet

NOZZLE CLEARING METHOD

	Description	Advantages	Disadvantages	Examples
Normal nozzle firing	All of the nozzles are fired periodically, before the ink has a chance to dry. When not in use the nozzles are sealed (capped) against air. The nozzle firing is usually performed during a special clearing cycle, after first moving the print head to a cleaning station.	No added complexity on the print head	May not be sufficient to displace dried ink	Most ink jet systems IJ01, IJ02, IJ03, IJ04, IJ05, IJ06, IJ07, IJ09, IJ10, IJ11, IJ12, IJ14, IJ16, IJ20, IJ22, IJ23, IJ24, IJ25, IJ26, IJ27, IJ28, IJ29, IJ30, IJ31, IJ32, IJ33, IJ34, 1336, IJ37, IJ38, IJ39, IJ40,, IJ41, IJ42, IJ43, IJ44,, IJ45
Extra power to ink heater	In systems which heat the ink, but do not boil it under normal situations, nozzle clearing can be achieved by over-powering the heater and boiling ink at the nozzle.	Can be highly effective if the heater is adjacent to the nozzle	Requires higher drive voltage for clearing May require larger drive transistors	Silverbrook, EP 0771 658 A2 and related patent applications
Rapid succession-ion of actuator pulses	The actuator is fired in rapid succession. In some configurations, this may cause heat build-up at the nozzle which boils the ink, clearing the nozzle. In other situations, it may cause sufficient vibrations to dislodge clogged nozzles.	Does not require extra drive circuits on the print head Can be readily controlled and initiated by digital logic	Effectiveness depends substantially upon the configuration of the ink jet nozzle	May be used with: IJ01, IJ02, IJ03, IJ04, IJ05, IJ06, IJ07, IJ09, IJ10, IJ11, IJ14, IJ16, IJ20, IJ22, IJ23, IJ24, IJ25, IJ27, IJ28, IJ29, IJ30, IJ31, IJ32, IJ33, IJ34, IJ36, IJ37, IJ38, IJ39, IJ40, IJ41, IJ42, IJ43, IJ44, IJ45
Extra power to ink pushing actuator	Where an actuator is not normally driven to the limit of its motion, nozzle clearing may be assisted by providing an enhanced drive signal to the actuator.	A simple solution where applicable	Not suitable where there is a hard limit to actuator movement	May be used with: IJ03, IJ09, IJ16, IJ20, IJ23, IJ24, IJ25, IJ27, IJ29, IJ30, IJ31, IJ32, IJ39, IJ40, IJ41, IJ42, IJ43, IJ44, IJ45
Acoustic resonance	An ultrasonic wave is applied to the ink chamber. This wave is of an appropriate amplitude and frequency to cause sufficient force at the nozzle to clear blockages. This is easiest to achieve if the ultrasonic wave is at a resonant frequency of the ink cavity.	A high nozzle clearing capability can be achieved May be implemented at very low cost in systems which already include acoustic actuators	High implementation cost if system does not already include an acoustic actuator	IJ08, IJ13, IJ15, IJ17, IJ18, IJ19, IJ21
Nozzle	A microfabricated	Can clear	Accurate	Silverbrook, EP

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NOZZLE CLEARING METHOD

	Description	Advantages	Disadvantages	Examples
clearing plate	plate is pushed against the nozzles. The plate has a post for every nozzle. A post moves through each nozzle, displacing dried ink.	severely clogged nozzles	mechanical alignment is required Moving parts are required There is risk of damage to the nozzles Accurate fabrication is required	0771 658 A2 and related patent applications
Ink pressure pulse	The pressure of the ink is temporarily increased so that ink streams from all of the nozzles. This may be used in conjunction with actuator energizing.	May be effective where other methods cannot be used	Requires pressure pump or other pressure actuator Expensive Wasteful of ink	May be used with all IJ series ink jets
Print head wiper	A flexible 'blade' is wiped across the print head surface. The blade is usually fabricated from a flexible polymer, e.g. rubber or synthetic elastomer.	Effective for planar print head surfaces Low cost	Difficult to use if print head surface is non-planar or very fragile Requires mechanical parts Blade can wear out in high volume print systems	Many ink jet systems
Separate ink boiling heater	A separate heater is provided at the nozzle although the normal drop ejection mechanism does not require it. The heaters do not require individual drive circuits, as many nozzles can be cleared simultaneously, and no imaging is required.	Can be effective where other nozzle clearing methods cannot be used Can be implemented at no additional cost in some ink jet configurations	Fabrication complexity	Can be used with many IJ series ink jets

NOZZLE PLATE CONSTRUCTION

	Description	Advantages	Disadvantages	Examples
Electro-formed nickel	A nozzle plate is separately fabricated from electroformed nickel, and bonded to the print head chip.	Fabrication simplicity	High temperatures and pressures are required to bond nozzle plate Minimum thickness constraints Differential thermal expansion	Hewlett Packard Thermal Ink jet
Laser ablated or drilled polymer	Individual nozzle holes are ablated by an intense UV laser in a nozzle plate, which is typically a polymer such as polyimide or polysulphone	No masks required Can be quite fast Some control over nozzle profile is possible Equipment required is relatively low cost	Each hole must be individually formed Special equipment required Slow where there are many thousands of nozzles per print head May produce thin burrs at exit holes	Canon Bubblejet 1988 Sercel et al., SPIE, Vol. 998 Excimer Beam Applications, pp. 76-83 1993 Watanabe et al., U.S. Pat. No. 5,208,604
Silicon micro-machined	A separate nozzle plate is micromachined from single crystal silicon, and bonded to the	High accuracy is attainable	Two part construction High cost Requires precision alignment	K. Bean, IEEE Transactions on Electron Devices, Vol. ED-25, No. 10, 1978, pp 1185-1195

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<u>NOZZLE PLATE CONSTRUCTION</u>				
	Description	Advantages	Disadvantages	Examples
	print head wafer.		Nozzles may be clogged by adhesive	Xerox 1990 Hawkins et al., U.S. Pat. No. 4,899,181
Glass capillaries	Fine glass capillaries are drawn from glass tubing. This method has been used for making individual nozzles, but is difficult to use for bulk manufacturing of print heads with thousands of nozzles.	No expensive equipment required Simple to make single nozzles	Very small nozzle sizes are difficult to form Not suited for mass production	1970 Zoltan U.S. Pat. No. 3,683,212
Monolithic, surface micro-machined using VLSI litho-graphic processes	The nozzle plate is deposited as a layer using standard VLSI deposition techniques. Nozzles are etched in the nozzle plate using VLSI lithography and etching.	High accuracy (<1 μm) Monolithic Low cost Existing processes can be used	Requires sacrificial layer under the nozzle plate to form the nozzle chamber Surface may be fragile to the touch	Silverbrook, EP 0771 658 A2 and related patent applications IJ01, IJ02, IJ04, IJ11, IJ12, IJ17, IJ18, IJ20, IJ22, IJ24, IJ27, IJ28, IJ29, IJ30, IJ31, IJ32, IJ33, IJ34, IJ36, IJ37, IJ38, 1339, IJ40, IJ41, IJ42, IJ43, IJ44
Monolithic, etched through substrate	The nozzle plate is a buried etch stop in the wafer. Nozzle chambers are etched in the front of the wafer, and the wafer is thinned from the back side. Nozzles are then etched in the etch stop layer.	High accuracy (<1 μm) Monolithic Low cost No differential expansion	Requires long etch times Requires a support wafer	IJ03, IJ05, IJ06, IJ07, IJ08, IJ09, IJ10, IJ13, IJ14, IJ15, IJ16, IJ19, IJ21, IJ23, IJ25, IJ26
No nozzle plate	Various methods have been tried to eliminate the nozzles entirely, to prevent nozzle clogging. These include thermal bubble mechanisms and acoustic lens mechanisms	No nozzles to become clogged	Difficult to control drop position accurately Crosstalk problems	Ricoh 1995 Sekiya et al U.S. Pat. No. 5,412,413 1993 Hadimioglu et al EUP 550,192 1993 Elrod et al EUP 572,220
Trough	Each drop ejector has a trough through which a paddle moves. There is no nozzle plate.	Reduced manufacturing complexity Monolithic	Drop firing direction is sensitive to wicking.	IJ35
Nozzle slit instead of individual nozzles	The elimination of nozzle holes and replacement by a slit encompassing many actuator positions reduces nozzle clogging, but increases crosstalk due to ink surface waves	No nozzles to become clogged	Difficult to control drop position accurately Crosstalk problems	1989 Saito et al U.S. Pat. No. 4,799,068

DROP EJECTION DIRECTION				
	Description	Advantages	Disadvantages	Examples
Edge ('edge shooter')	Ink flow is along the surface of the chip, and ink drops are ejected from the chip edge	Simple construction No silicon etching required Good heat sinking via substrate Mechanically strong Ease of chip handling	Nozzles limited to edge High resolution is difficult Fast color printing requires one print head per color	Canon Bubblejet 1979 Endo et al GB patent 2,007,162 Xerox heater-in-pit 1990 Hawkins et al U.S. Pat. No. 4,899,181 Tone-jet
Surface ('roof shooter')	Ink flow is along the surface of the chip, and ink drops are ejected from the chip surface, normal to the plane of the chip.	No bulk silicon etching required Silicon can make an effective heat sink Mechanical strength	Maximum ink flow is severely restricted	Hewlett-Packard TIJ 1982 Vaught et al U.S. Pat. No. 4,490,728 IJ02, IJ11, IJ12, IJ20, IJ22
Through chip, forward ('up shooter')	Ink flow is through the chip, and ink drops are ejected from the front surface of the chip.	High ink flow Suitable for pagewidth print heads High nozzle packing density therefore low manufacturing cost	Requires bulk silicon etching	Silverbrook, EP 0771 658 A2 and related patent applications IJ04, IJ17, IJ18, IJ24, IJ27-IJ45
Through chip, reverse ('down shooter')	Ink flow is through the chip, and ink drops are ejected from the rear surface of the chip.	High ink flow Suitable for pagewidth print heads High nozzle packing density therefore low manufacturing cost	Requires wafer thinning Requires special handling during manufacture	IJ01, IJ03, IJ05, IJ06, IJ07, IJ08, IJ09, IJ10, IJ13, IJ14, IJ15, IJ16, IJ19, IJ21, IJ23, IJ25, IJ26
Through actuator	Ink flow is through the actuator, which is not fabricated as part of the same substrate as the drive transistors.	Suitable for piezoelectric print heads	Pagewidth print heads require several thousand connections to drive circuits Cannot be manufactured in standard CMOS fabs Complex assembly required	Epson Stylus Tektronix hot melt piezoelectric ink jets

INK TYPE

	Description	Advantages	Disadvantages	Examples
Aqueous, dye	Water based ink which typically contains: water, dye, surfactant, humectant, and biocide. Modern ink dyes have high water-fastness, light fastness	Environmentally friendly No odor	Slow drying Corrosive Bleeds on paper May strike through Cockles paper	Most existing ink jets All IJ series ink jets Silverbrook, EP 0771 658 A2 and related patent applications IJ02, IJ04, IJ21, IJ26, IJ27, IJ30 Silverbrook, EP 0771 658 A2 and related patent applications Piezoelectric ink jets Thermal ink jets (with significant restrictions)
Aqueous, pigment	Water based ink which typically contains: water, pigment, surfactant, humectant, and biocide. Pigments have an advantage in reduced bleed, wicking and strike through.	Environmentally friendly No odor Reduced bleed Reduced wicking Reduced strike through	Slow drying Corrosive Pigment may clog nozzles Pigment may clog actuator mechanisms Cockles paper	IJ02, IJ04, IJ21, IJ26, IJ27, IJ30 Silverbrook, EP 0771 658 A2 and related patent applications Piezoelectric ink jets Thermal ink jets (with significant restrictions)
Methyl Ethyl Ketone (MEK)	MEK is a highly volatile solvent used for industrial printing on difficult surfaces such as aluminum cans.	Very fast drying Prints on various substrates such as metals and plastics	Odorous Flammable	All IJ series ink jets
Alcohol (ethanol 2-butanol, and others)	Alcohol based inks can be used where the printer must operate at temperatures below the freezing point of water. An example of this is in-camera consumer photographic printing.	Fast drying Operates at sub-freezing temperatures Reduced paper cockle Low cost	Slight odor Flammable	All IJ series ink jets
Phase change (hot melt)	The ink is solid at room temperature, and is melted in the print head before jetting. Hot melt inks are usually wax based, with a melting point around 80° C. After jetting the ink freezes almost instantly upon contacting the print medium or a transfer roller.	No drying time-ink instantly freezes on the print medium Almost any print medium can be used No paper cockle occurs No wicking occurs No bleed occurs No strikethrough occurs	High viscosity Printed ink typically has a 'waxy' feel Printed pages may 'block' Ink temperature may be above the curie point of permanent magnets Ink heaters consume power Long warm-up time	Tektronix hot melt piezoelectric ink jets 1989 Nowak U.S. Pat. No. 4,820,346 All IJ series ink jets
Oil	Oil based inks are extensively used in offset printing. They have advantages in improved characteristics on paper (especially no wicking or cockle). Oil soluble dies and pigments are required.	High solubility medium for some dyes Does not cockle paper Does not wick through paper	High viscosity: this is a significant jets limitation for use in ink jets, which usually require a low viscosity. Some short chain and multi-branched oils have a sufficiently low viscosity. Slow drying	All IJ series ink
Micro-emulsion	A microemulsion is a stable, self forming emulsion of oil, water, and surfactant. The characteristic drop size is less than 100 nm, and is determined by the preferred curvature of the surfactant.	Stops ink bleed High dye solubility Water, oil, and amphiphilic soluble dies can be used Can stabilize pigment suspensions	Viscosity higher than water Cost is slightly higher than water based ink High surfactant concentration required (around 5%)	All IJ series ink jets

We claim:

1. A method of manufacture of an ink jet printhead, said method comprising the steps of:
 - providing an initial semiconductor wafer having an electrical circuitry layer formed thereon;
 - etching a series of slots in at least the circuitry layer to define a nozzle cavity inlet;
 - depositing a first layer of magnetic flux material on the electrical circuitry layer and etching the flux material to define a fixed magnetic plate;
 - depositing an insulating layer on the first layer of magnetic flux material and on the electrical circuitry layer and etching vias for a subsequent conductive layer;
 - depositing a conductive layer and etching the conductive layer to define a conductive coil conductively interconnected to the electrical circuitry layer;
 - depositing a hydrophobic material layer in the region of the conductive coil and etching the hydrophobic material layer;
 - depositing a sacrificial material layer in the region of the fixed magnetic plate and the coil and etching the sacrificial material layer to define a cavity for a plunger incorporating walls of a nozzle chamber;
 - depositing a second layer of magnetic flux material over the sacrificial material and etching the second layer to form the plunger to substantially enclose the conductive coil;

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- etching away the sacrificial material; and
- etching an ink supply channel through the wafer to be in fluid communication with the nozzle chamber.
2. A method as claimed in claim 1 which further comprises forming a series of springs connected to the plunger for biasing the plunger away from the fixed magnetic plate.
3. A method as claimed in claim 1 wherein said conductive layer comprises substantially copper.
4. A method as claimed in claim 1 which includes etching vias to allow for the electrical interconnection of portions of subsequent layers.
5. A method as claimed in claim 1 wherein the magnetic flux material comprises substantially a cobalt nickel iron alloy.
6. A method as claimed in claim 1 wherein the wafer comprises a double-sided polished CMOS wafer.
7. A method as claimed in claim 1 which includes etching the ink supply channel from a back surface of the wafer.
8. A method as claimed in claim 1 in which the wafer is separated into printhead chips.

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